



# Destructive Single-Event Effects in Diodes

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and Kenneth A. LaBel<sup>1</sup>

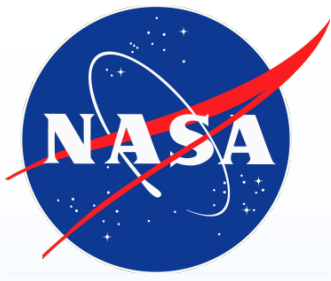
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# Acronyms

- DUT – Device Under Test
- EDS – Energy Dispersive X-Ray Spectroscopy
- ETW – Electronics Technology Workshop
- GSFC – Goddard Space Flight Center
- $I_F$  – Forward Current
- $I_R$  – Reverse Current
- IR – infrared
- LET – Linear Energy Transfer
- NEPP – NASA Electronics Parts and Packaging
- RF – Radio Frequency
- SBD – Super Barrier Diode
- SEE – Single-Event Effects
- $V_R$  – Reverse Voltage
- $V_F$  – Forward Voltage

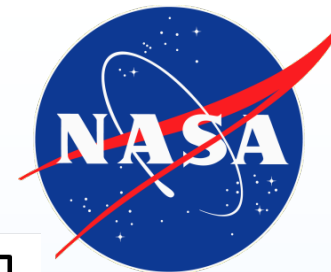


# Background and Summary of Previous Results

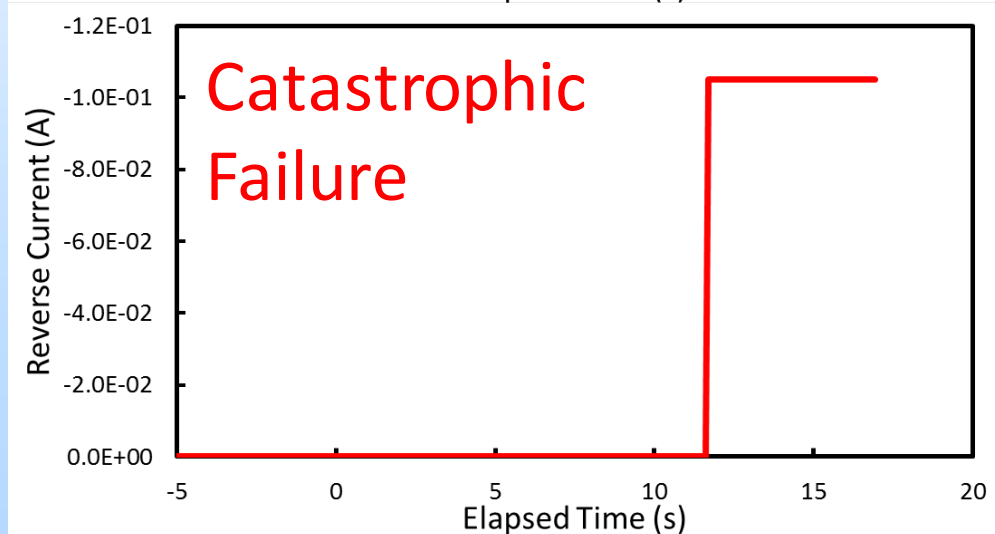
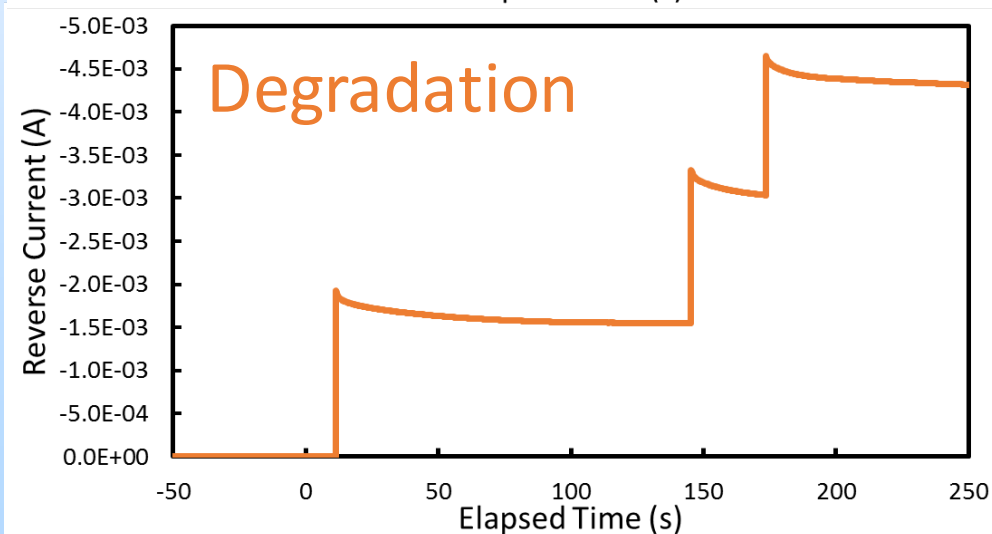
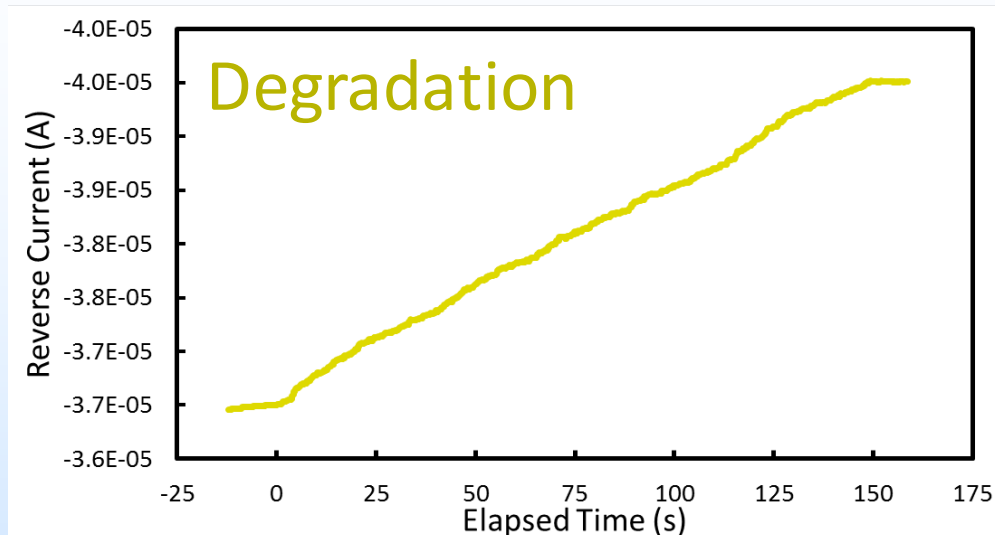
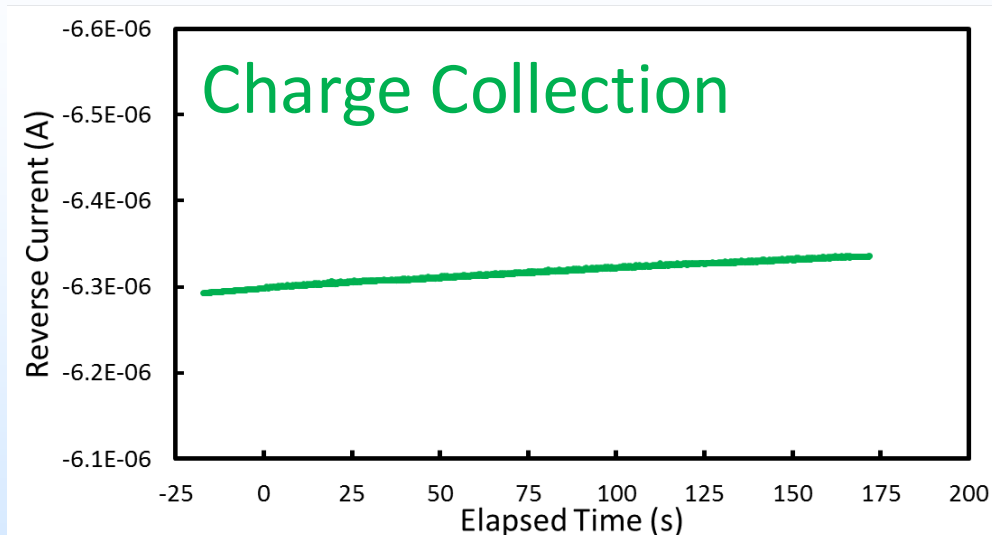


# Introduction

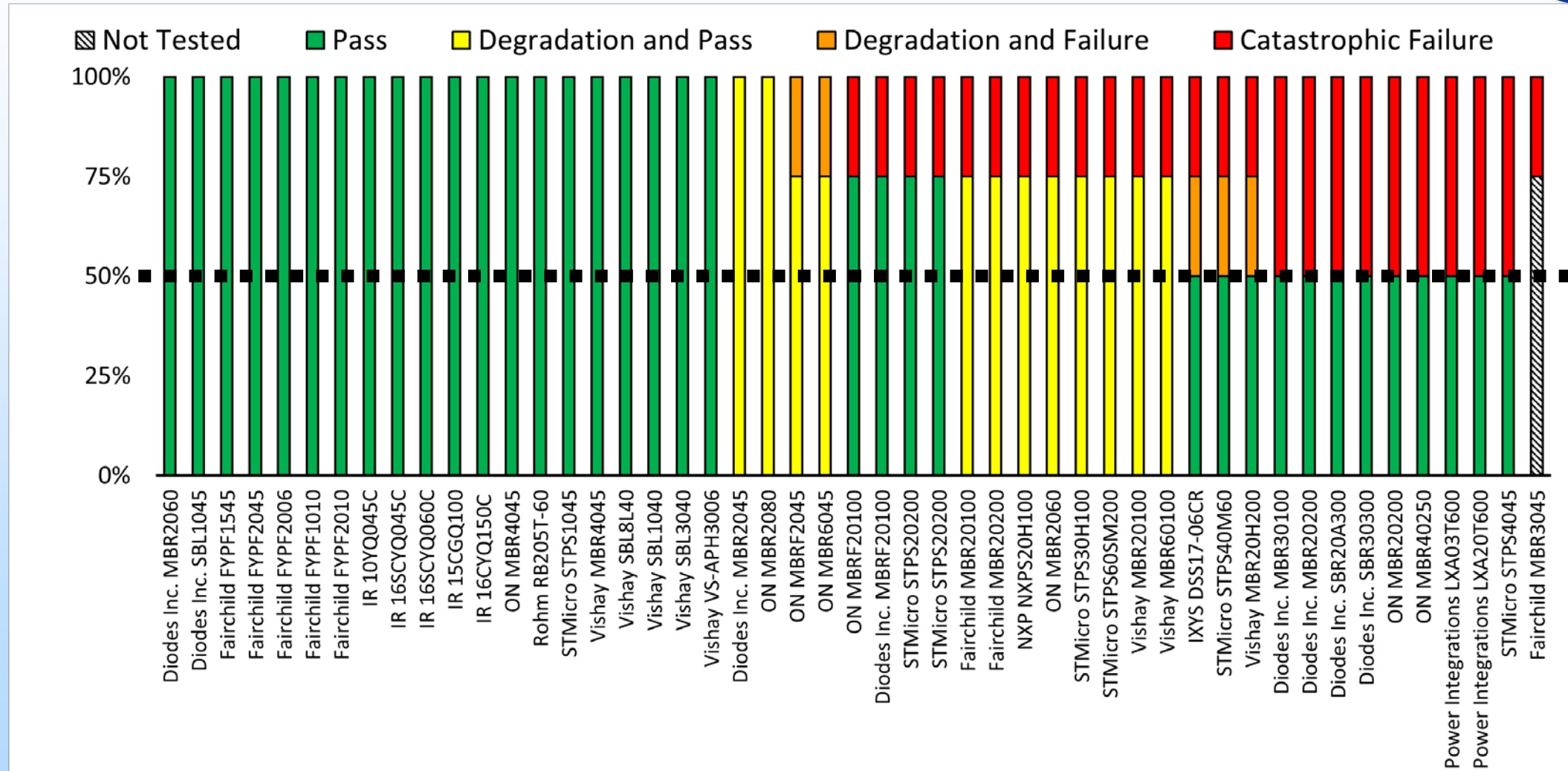
- Since 2011, GSFC has been investigating destructive SEEs in Schottky diodes
  - We have recommended a 50%  $V_R$  derating for operation in heavy-ion environments
- During this investigation, several super barrier diodes were also irradiated and experienced failures identical to the Schottky diodes that were tested
  - In retrospect, this is not totally unexpected as SBDs also have a Schottky junction, but also employs an insulating layer between the metal and semiconductor material
  - However, this led us to question whether the failure mechanism is limited to diodes with Schottky junctions or if it exists in other diode types as well



# Background – Observed Radiation Responses



# Background – Schottky Diode Results

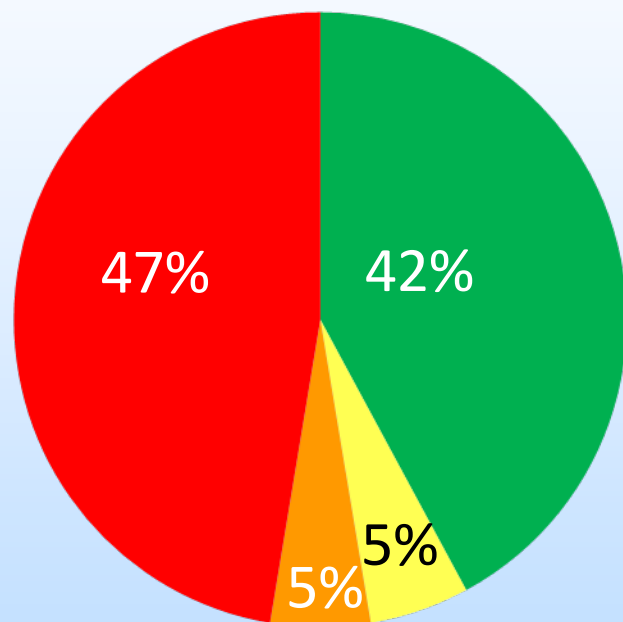


To be presented by Megan C. Casey at the NASA Electronics Parts and Packaging (NEPP) Electronics Technology Workshop (ETW), Greenbelt, MD, June 26-29, 2017.

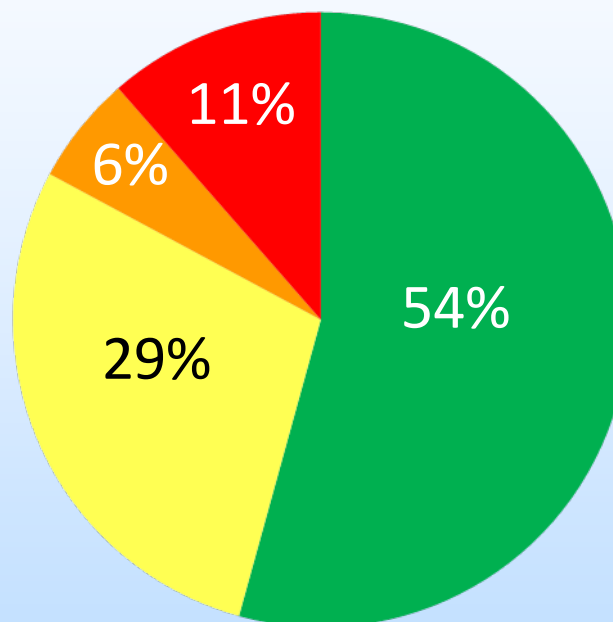


# Background – Schottky Diode Results

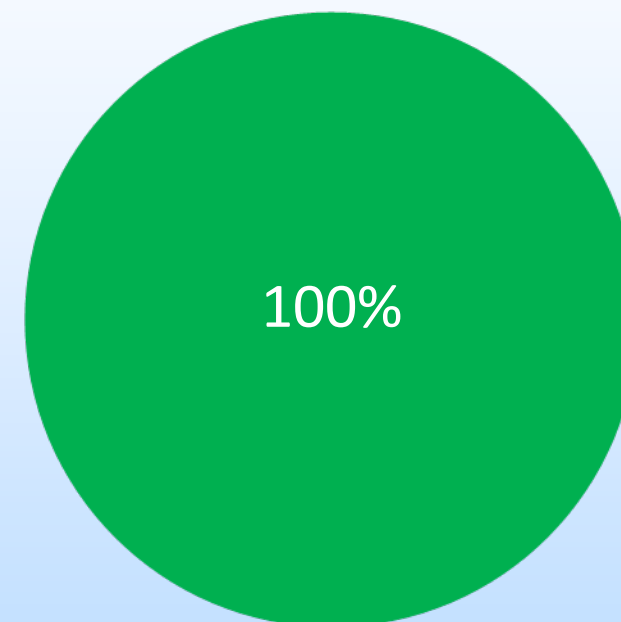
100% of Reverse Voltage



75% of Reverse Voltage



50% of Reverse Voltage



By derating to 50% of the reverse voltage, all failures are eliminated for the parts tested



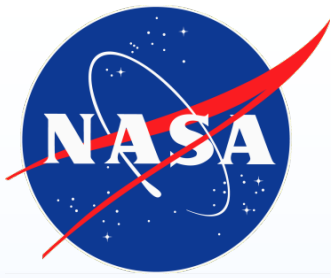
# Current Results – Other Diode Types





# Parts Tested

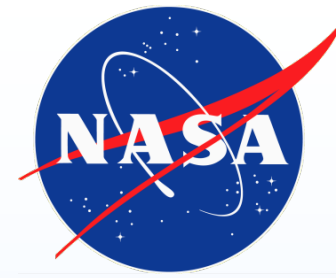
- 30 diodes from 10 manufacturers
- 5 diode types: avalanche, RF PiN, super barrier, switching, and Zener
- Reverse voltages range from 35 V to 200 V
- Forward currents (per diode) from 2 mA to 10 A



# Test Facilities and Technique

- All parts were tested at LBNL's 88-inch cyclotron with 1233 MeV Xe (LET = 58.8 MeV-cm<sup>2</sup>/mg)
- All diodes were irradiated under reverse bias and at room temperature
- After each beam run,  $V_F$ ,  $V_R$ ,  $I_F$  and  $I_R$  were measured
- Because a 50% derating has been found to be sufficient for Schottky diodes, that was the initial test voltage
- A minimum of 3 DUTs per part type were tested

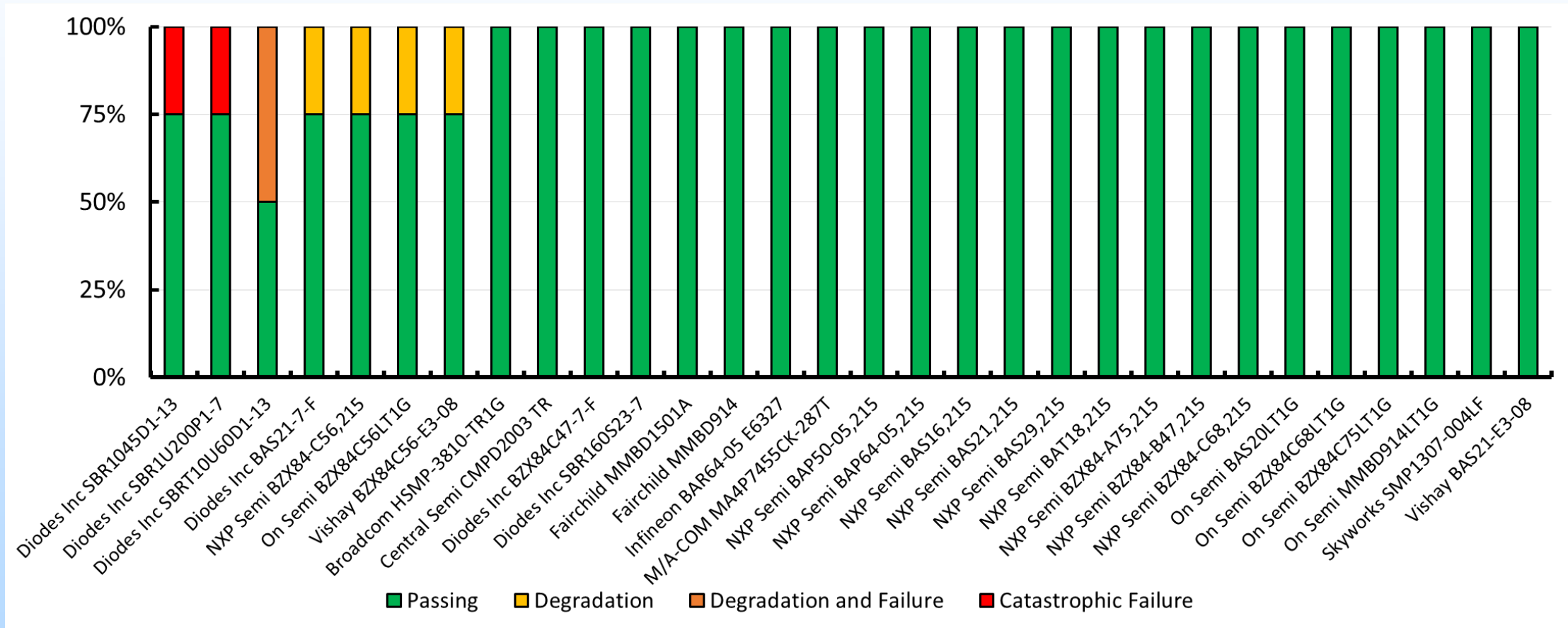
# Diodes Tested



Diode Type	Manufacturer	Part Number	Reverse Voltage	Forward Current
Avalanche	NXP Semi	BAS29,215	90 V	200 mA
Super Barrier	Diodes Inc	SBR1U200P1-7	200 V	1 A
Super Barrier	Diodes Inc	SBR1045D1-13	45 V	10 A
Super Barrier	Diodes Inc	SBR160S23-7	60 V	900 mA
Super Barrier	Diodes Inc	SBRT10U60D1-13	60 V	10 A
Zener	Diodes Inc	BZX84C47-7-F	47 V	10 mA
Zener	NXP Semi	BZX84-B47,215	47 V	10 mA
Zener	NXP Semi	BZX84-C56,215	56 V	10 mA
Zener	NXP Semi	BZX84-C68,215	68 V	10 mA
Zener	NXP Semi	BZX84-A75,215	75 V	10 mA
Zener	On Semi	BZX84C56LT1G	56 V	10 mA
Zener	On Semi	BZX84C68LT1G	68 V	10 mA
Zener	On Semi	BZX84C75LT1G	75 V	10 mA
Zener	Vishay	BZX84C56-E3-08	56 V	2 mA

Diode Type	Manufacturer	Part Number	Reverse Voltage	Forward Current
PiN	Broadcom	HSMP-3810-TR1G	100 V	1 A
PiN	Infineon	BAR64-05 E6327	150 V	100 mA
PiN	M/A-COM	MA4P7455CK-287T	100 V	150 mA
PiN	NXP Semi	BAP64-05,215	175 V	100 mA
PiN	NXP Semi	BAT18,215	35 V	100 mA
PiN	NXP Semi	BAP50-05,215	50 V	50 mA
PiN	Skyworks	SMP1307-004LF	200 V	100 mA
Switching	Central Semi	CMPD2003 TR	200 V	200 mA
Switching	Diodes Inc	BAS21-7-F	200 V	200 mA
Switching	Fairchild	MMBD914	100 V	200 mA
Switching	Fairchild	MMBD1501A	200 V	200 mA
Switching	NXP Semi	BAS16,215	100 V	215 mA
Switching	NXP Semi	BAS21,215	200 V	200 mA
Switching	On Semi	MMBD914LT1G	100 V	200 mA
Switching	On Semi	BAS20LT1G	200 V	200 mA
Switching	Vishay	BAS21-E3-08	200 V	200 mA

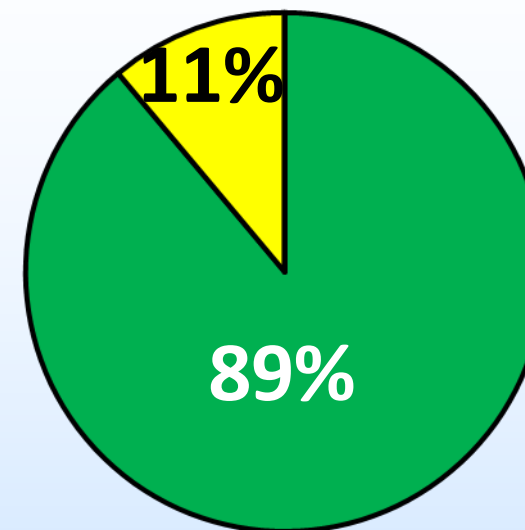
# Results



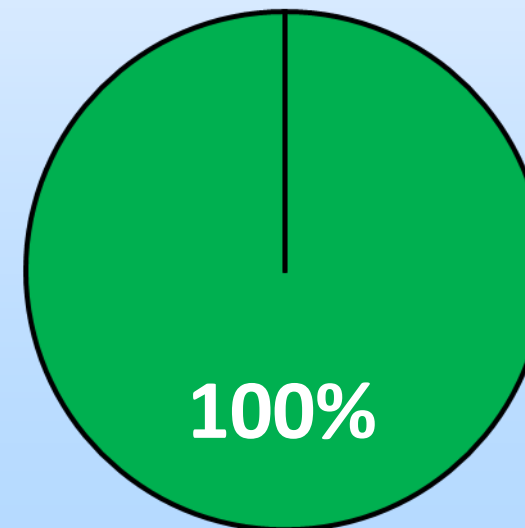


# Results – RF Switching Diodes

Manufacturer	Part Number	Reverse Voltage	Forward Current
Fairchild	MMBD914	100 V	200 mA
NXP Semi	BAS16,215	100 V	215 mA
On Semi	MMBD914LT1G	100 V	200 mA
Diodes Inc	BAS21-7-F	200 V	200 mA
Central Semi	CMPD2003 TR	200 V	200 mA
Fairchild	MMBD1501A	200 V	200 mA
NXP Semi	BAS21,215	200 V	200 mA
On Semi	BAS20LT1G	200 V	200 mA
Vishay	BAS21-E3-08	200 V	200 mA



100% of Rated  
Reverse Voltage

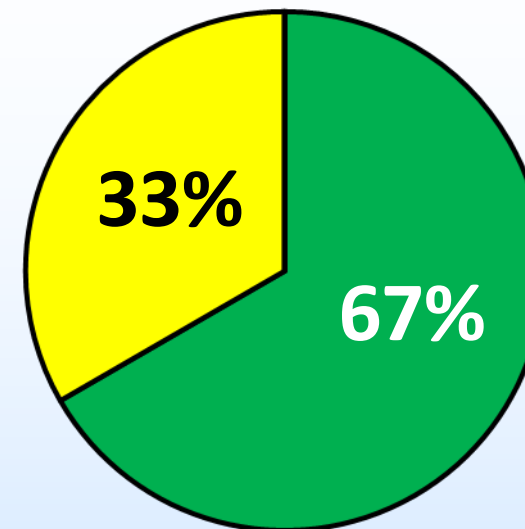


75% of Rated  
Reverse Voltage

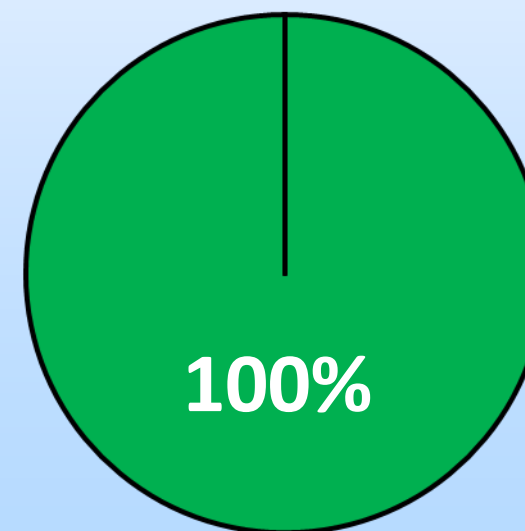


# Results – Zener Diodes

Manufacturer	Part Number	Zener Voltage	Forward Current
Diodes Inc	BZX84C47-7-F	47 V	10 mA
NXP Semi	BZX84-B47,215	47 V	10 mA
NXP Semi	BZX84-C56,215	56 V	10 mA
On Semi	BZX84C56LT1G	56 V	10 mA
Vishay	BZX84C56-E3-08	56 V	2 mA
NXP Semi	BZX84-C68,215	68 V	10 mA
On Semi	BZX84C68LT1G	68 V	10 mA
NXP Semi	BZX84-A75,215	75 V	10 mA
On Semi	BZX84C75LT1G	75 V	10 mA



100% of Rated  
Reverse Voltage

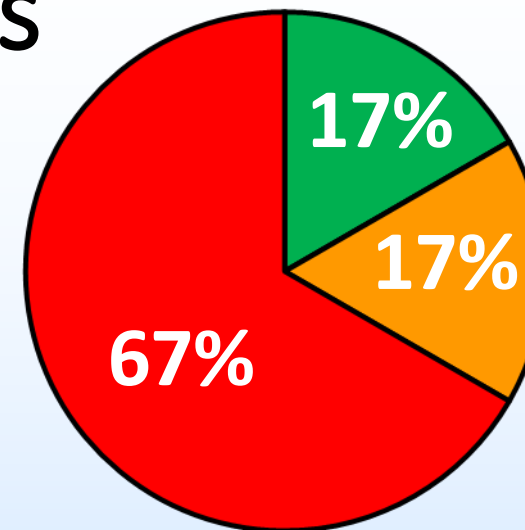


75% of Rated  
Reverse Voltage

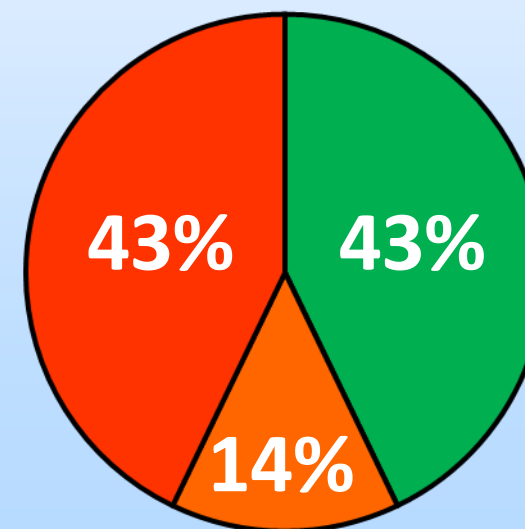


# Results – Super Barrier Diodes

Manufacturer	Part Number	Reverse Voltage	Forward Current
Diodes Inc	SBR1045D1-13	45 V	10 A
Diodes Inc	SBRT10U60D1-13	60 V	10 A
Diodes Inc	SBR160S23-7	60 V	900 mA
Diodes Inc	SBR1U200P1-7	200 V	1 A
Diodes Inc	SBR20A300	300 V	10 A
Diodes Inc	SBR30300	300 V	15 A



100% of Rated  
Reverse Voltage

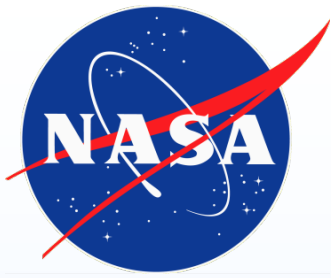


75% of Rated  
Reverse Voltage



# Recap of 2016 ETW Presentation





# 2016 NEPP ETW

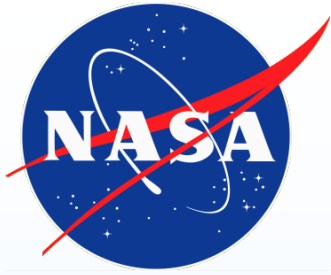
- Last year, I presented a case study of a 1N6843 from two different manufacturers being used on a flight project
  - The reverse voltage is 100 V and forward current is 10 A
  - Normal application reverse voltage is ~60 V and worst case application reverse voltage is ~82 V
  - There are currently no mission **radiation** requirements for diodes; so destructive SEEs requirements were used for this testing
- The irradiated parts experienced all four radiation responses
  - By conducting failure analysis on these DUTs, we are hoping to derive additional information about the failure mechanisms



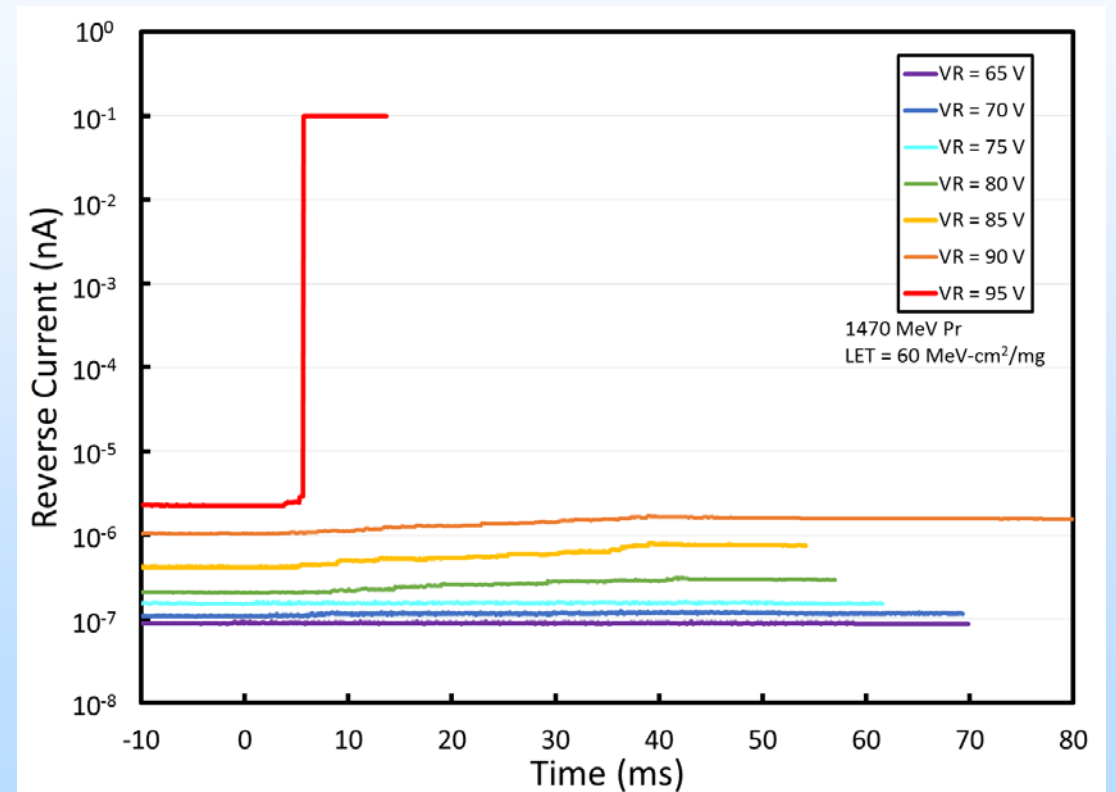
# Failure Analysis

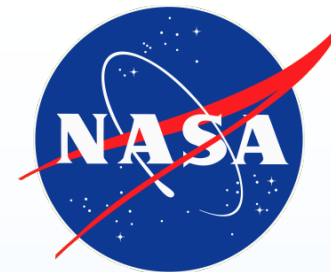
# Catastrophic Failure

## Power Supply Currents



- SN5 was irradiated with 1470 MeV Pr (LET = 60 MeV-cm<sup>2</sup>/mg) in 5 V steps starting at 50 V (50% of the rated reverse voltage)
- Only charge collection was observed up to the 65-V irradiation
- When biased at 70 V, small increases in the reverse current were observed during the beam run
  - Post-irradiation electrical parameter measurements all remained within specification
  - Increases in reverse current were on the order of 100 nA
- At 95 V, the increase in reverse current was 100s of nA

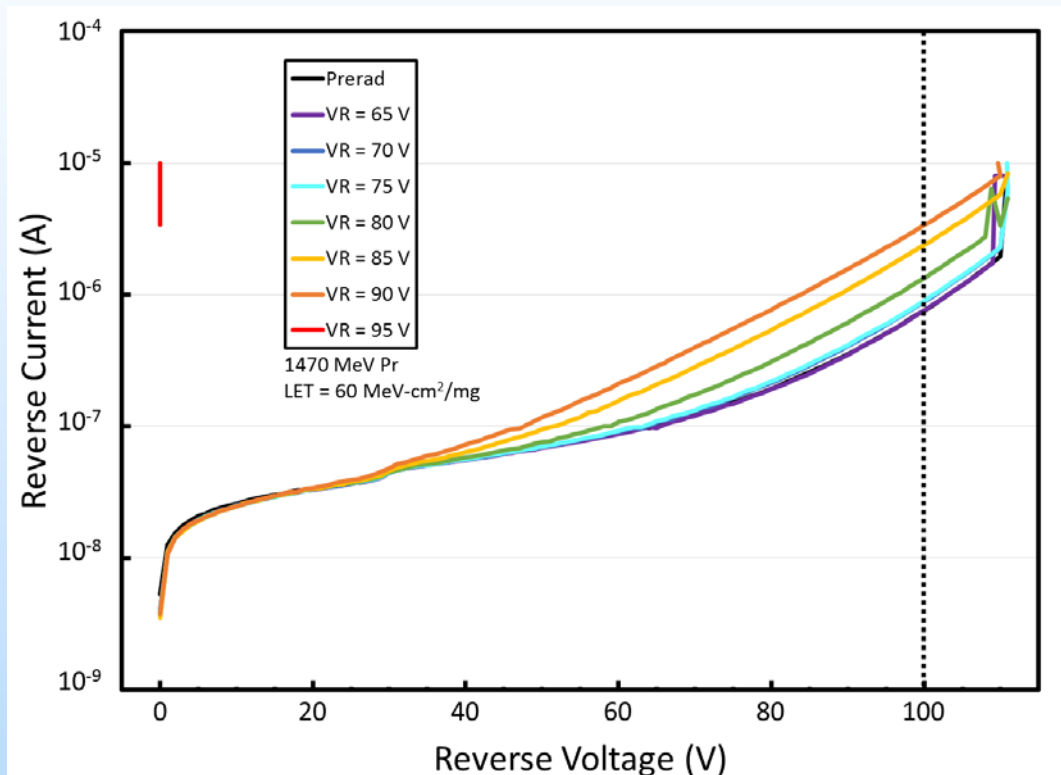




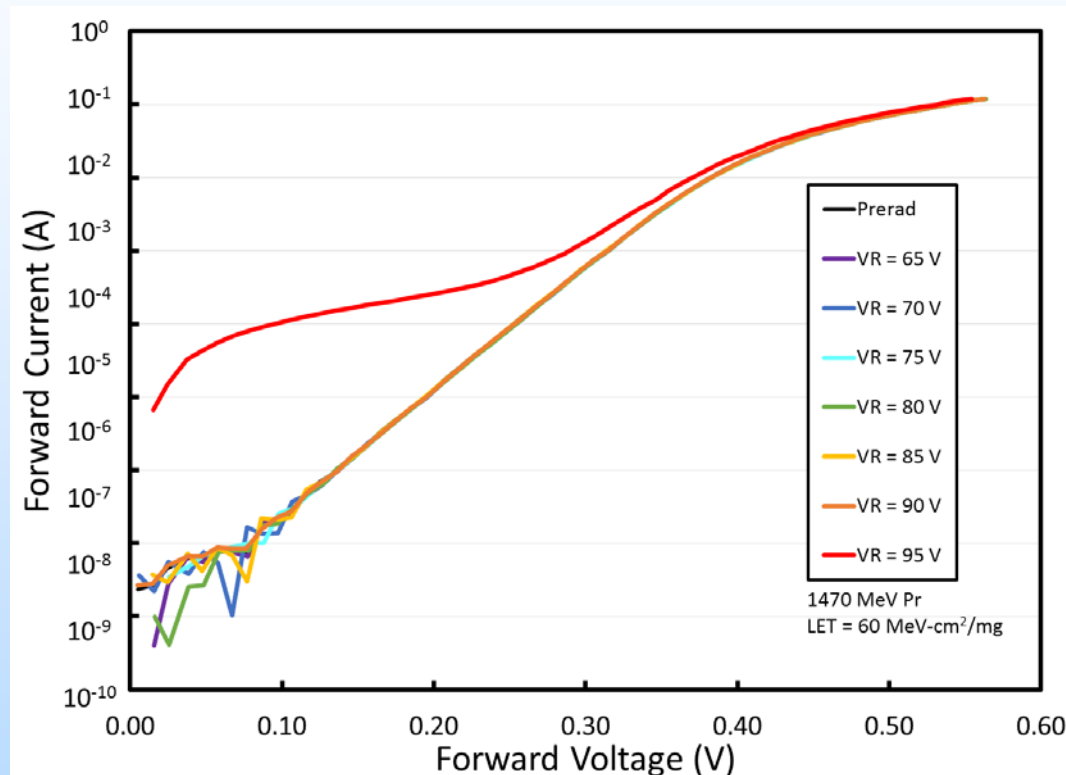
# Catastrophic Failure

## Post-Irradiation Electrical Measurements

### Reverse Current vs. Reverse Voltage



### Forward Current vs. Forward Voltage

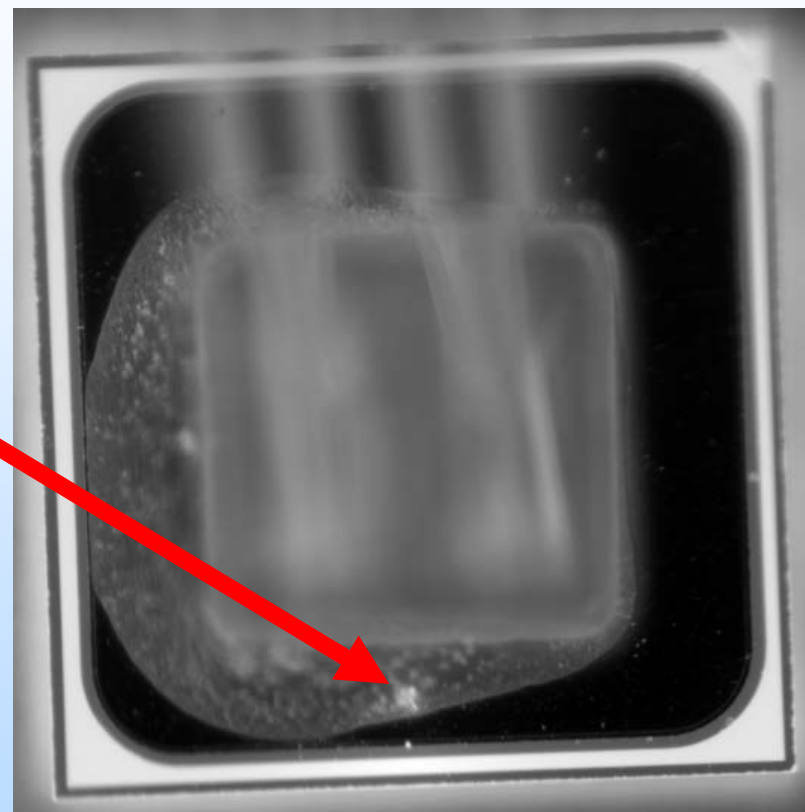


Part was degrading until after the 95-V run, and then  $I_R$  exceeded 10  $\mu$ A at less than 1 V

# Catastrophic Failure

## Infrared Imaging of DUT

- Diode was examined using an IR camera and pictures were taken with a small voltage applied
  - Bright white spot just below the wirebond contact is the location of the failure
- Low-magnitude and high-magnitude optical images of the surface of the DUT did not show anything unusual at the location identified in the IR image



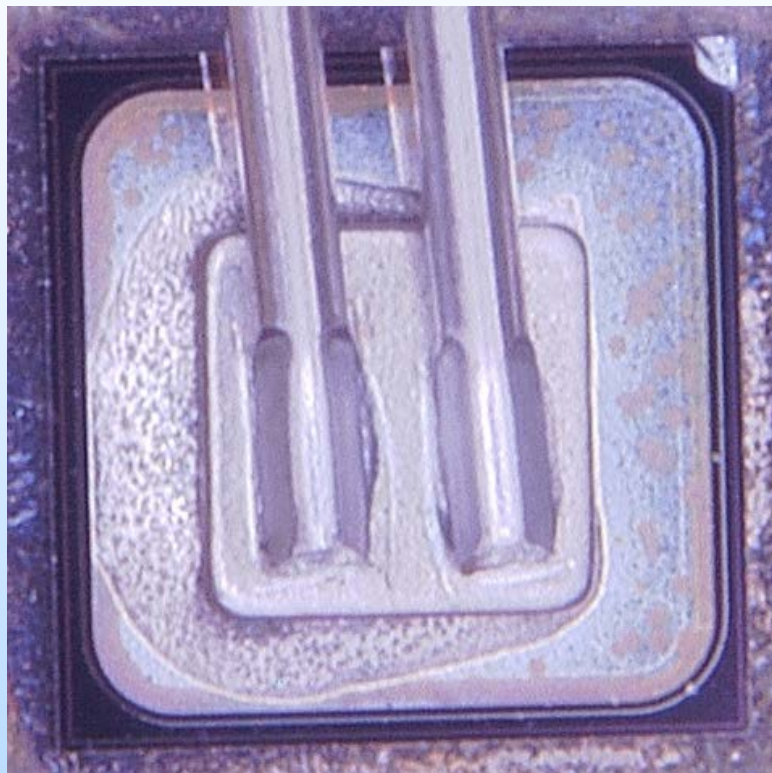




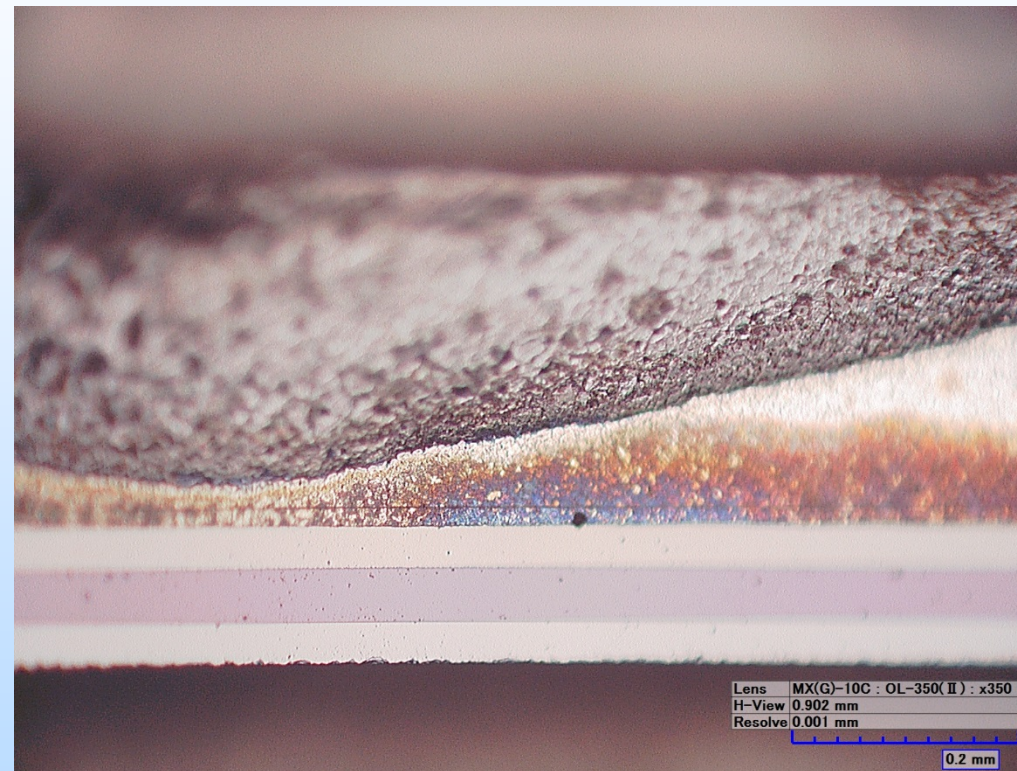
# Catastrophic Failure

Optical Images of DUT

**Low-Magnification**



**High-Magnification**



Failure location is not visible in optical images





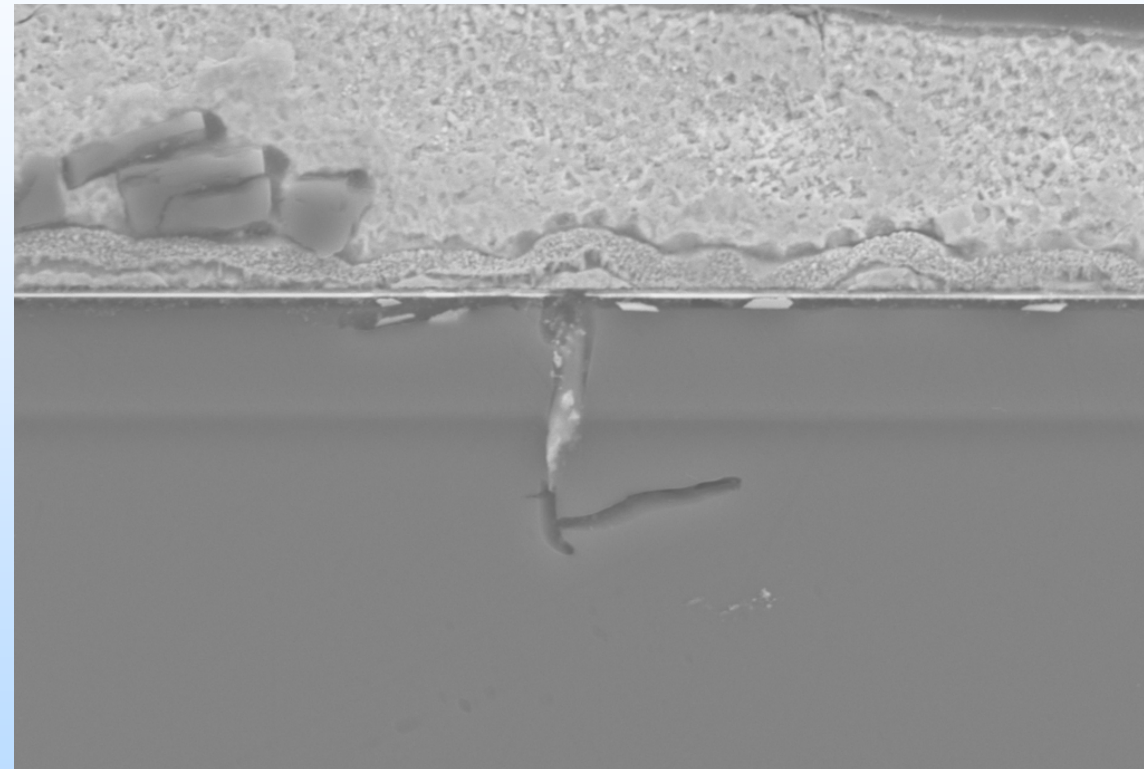
# Catastrophic Failure

Cross-Section at Failure Location

**High-Magnification Optical Image**



**Scanning Electron Microscope Image**



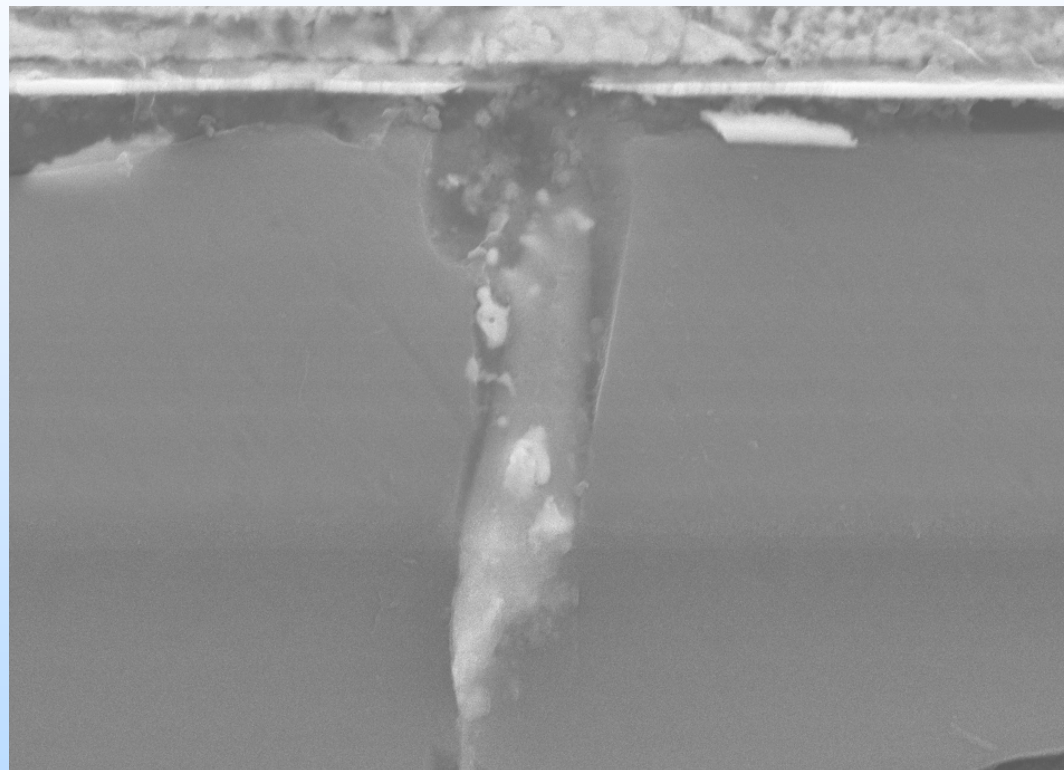




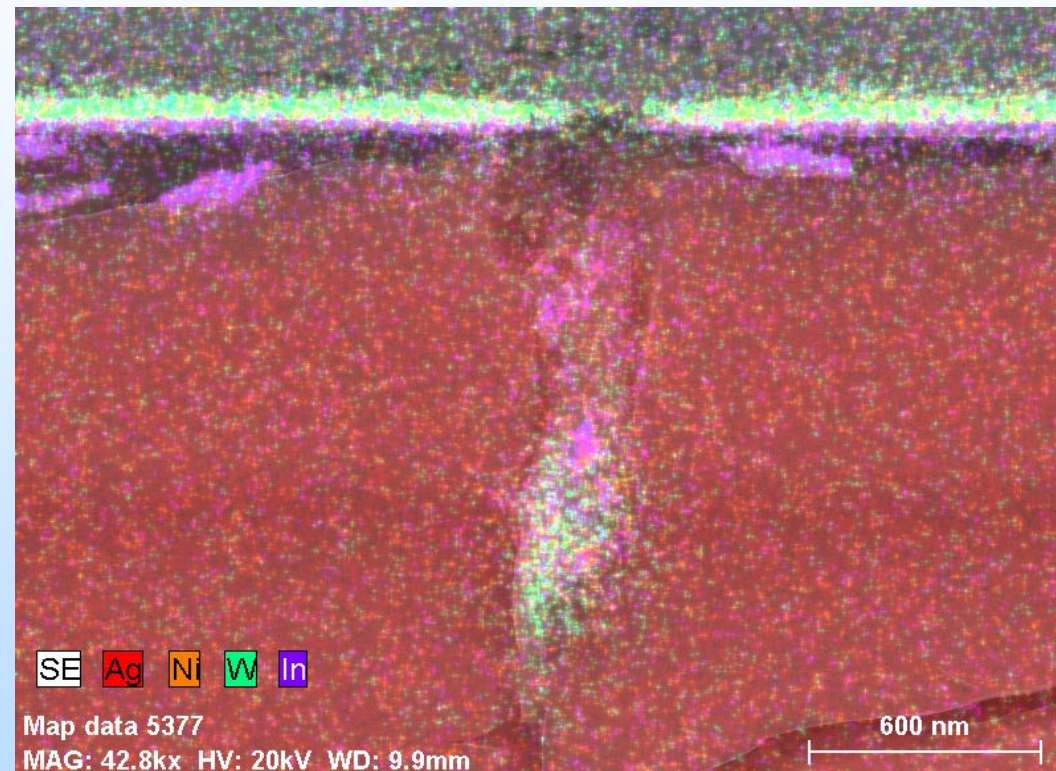
# Catastrophic Failure

Energy Dispersive X-Ray Spectroscopy

Magnification of SEM Image



Map of Ag, Ni, W, and In

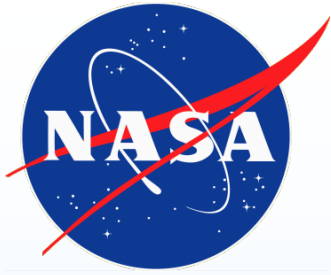


Metal has clearly displaced from Schottky junction into void  
formed from high current

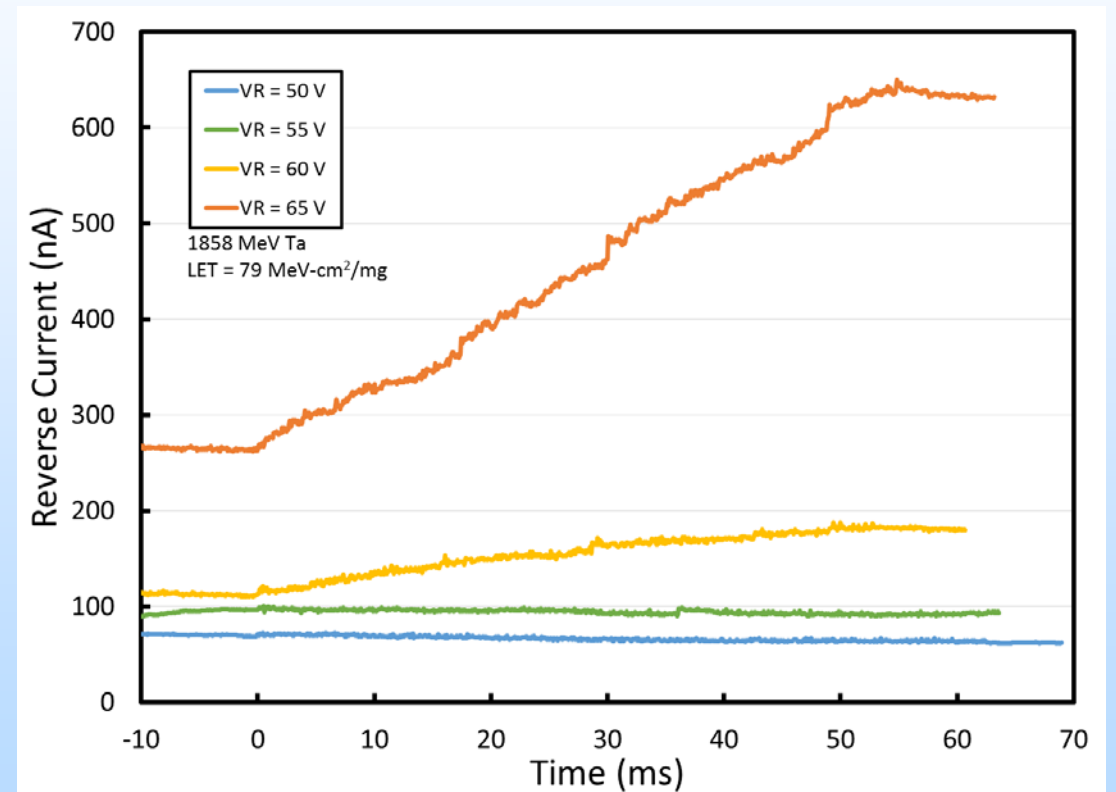


# Degradation and Failure

## Power Supply Currents

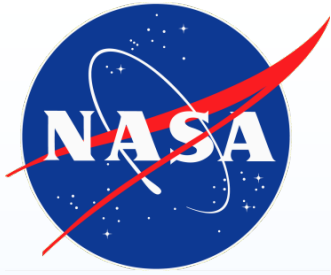


- SN2 was irradiated with 1858 MeV Ta (LET = 79 MeV-cm<sup>2</sup>/mg) in 5 V steps starting at 50 V (50% of the rated reverse voltage)
- Only charge collection was observed up to the 55-V irradiation
- When biased at 60 V, a ~60 nA increase in  $I_R$  was observed
  - All post-irradiation parameter measurements remained within specification
- At 65 V, however, DUT experienced 100s of nA in degradation and post-irradiation  $I_R$  measurement was out of specification

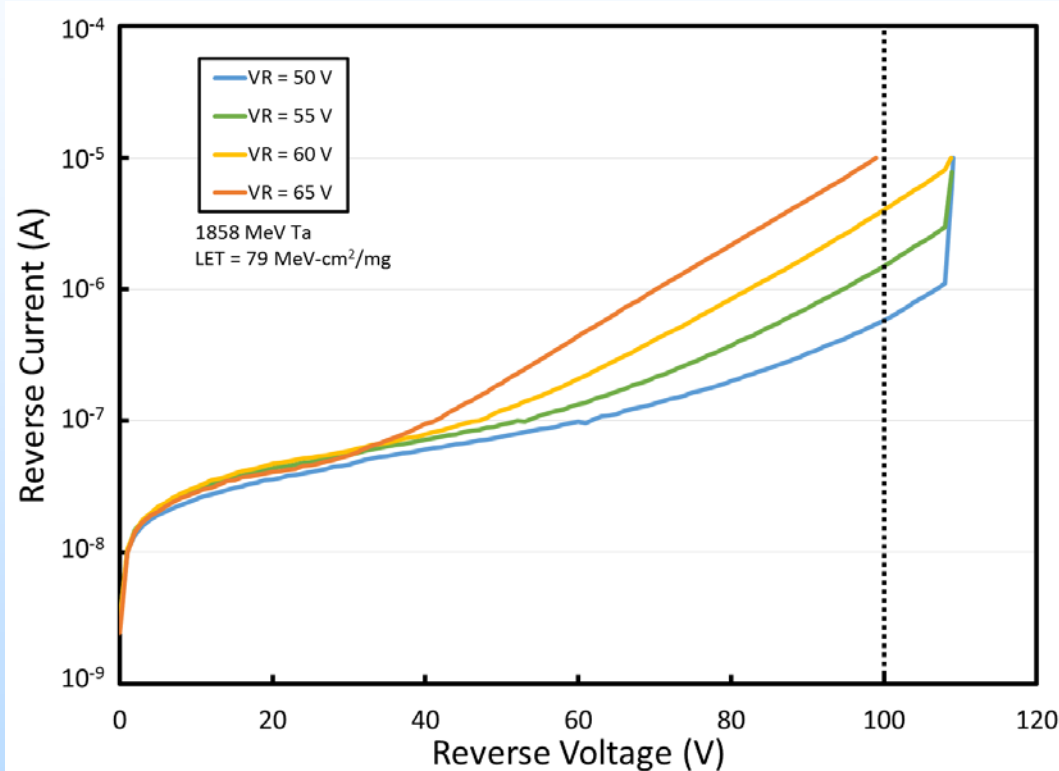


# Degradation and Failure

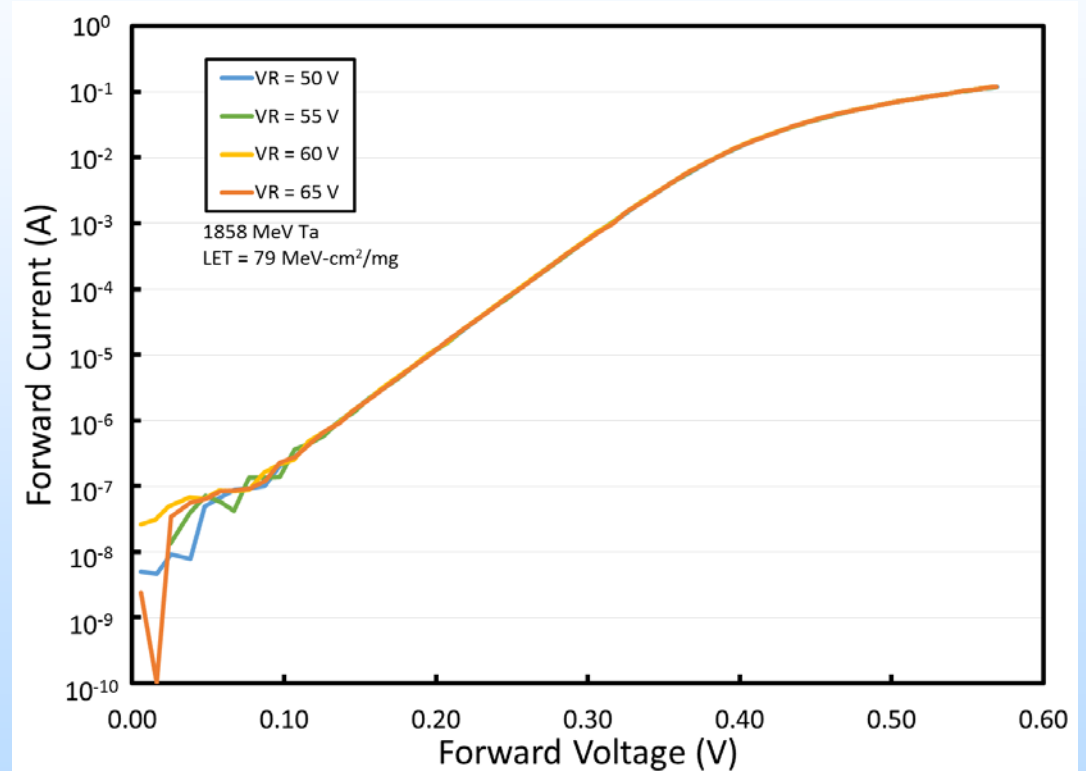
## Post-Irradiation Electrical Measurements



### Reverse Current vs. Reverse Voltage



### Forward Current vs. Forward Voltage



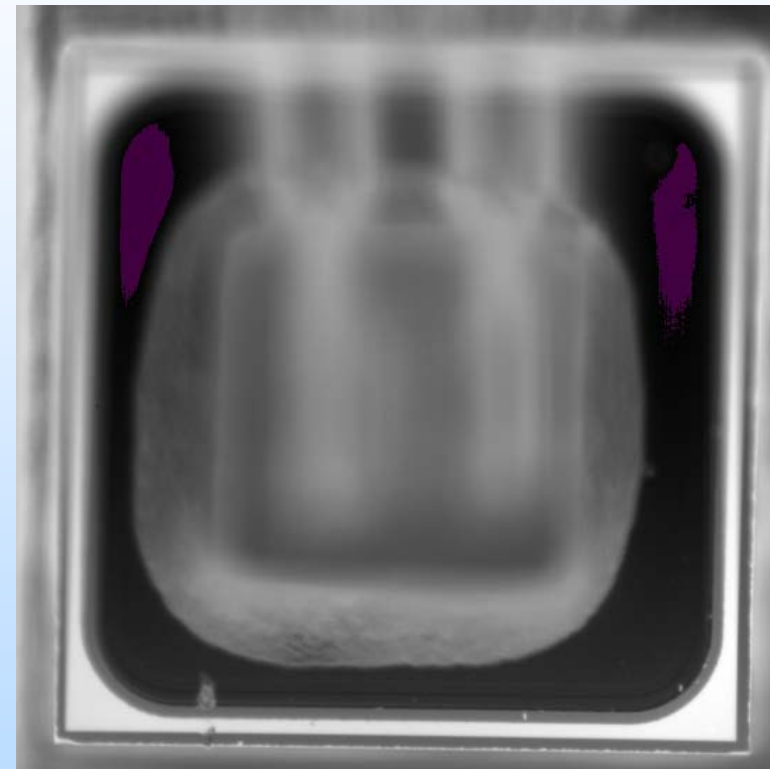
No significant changes were observed in the  $I_F$ - $V_F$  curves, but  $I_R$  exceeded specification at less than 100 V



# Degradation and Failure

## Infrared Imaging of DUT

- Diode was examined using an IR camera and pictures were taken with a small voltage applied
  - No failure locations could be identified
- Low-magnitude and high-magnitude optical images of the surface of the DUT also did not show anything unusual
- Because no failure locations were identified, a different technique had to be used
  - A series of chemical etches were used to remove the contact pad, solder connection, and Schottky barrier metal



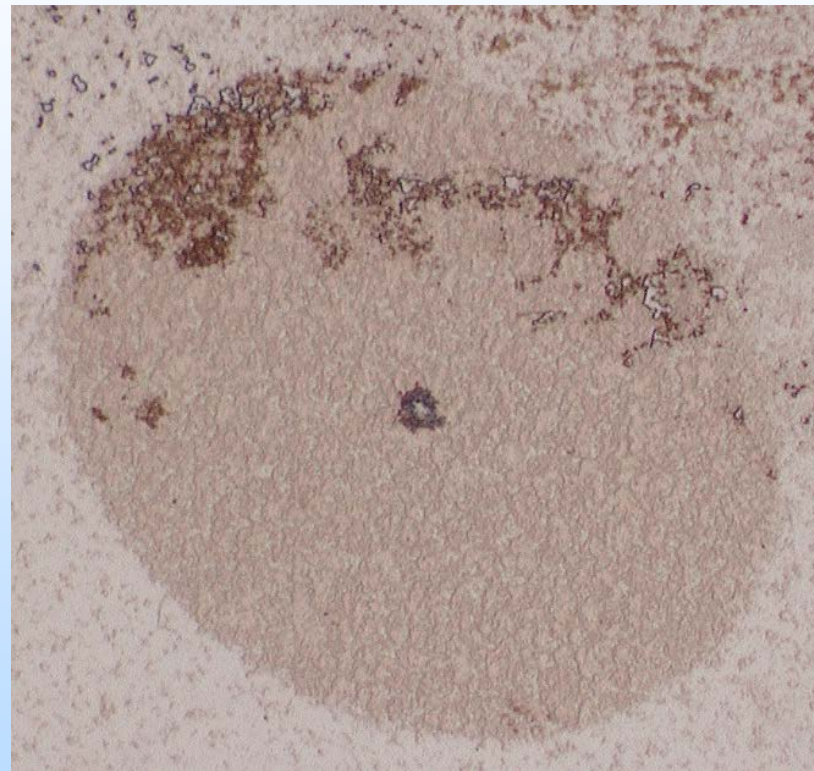
# Degradation and Failure

Optical Images of DUT

**Low-Magnification**



**High-Magnification**

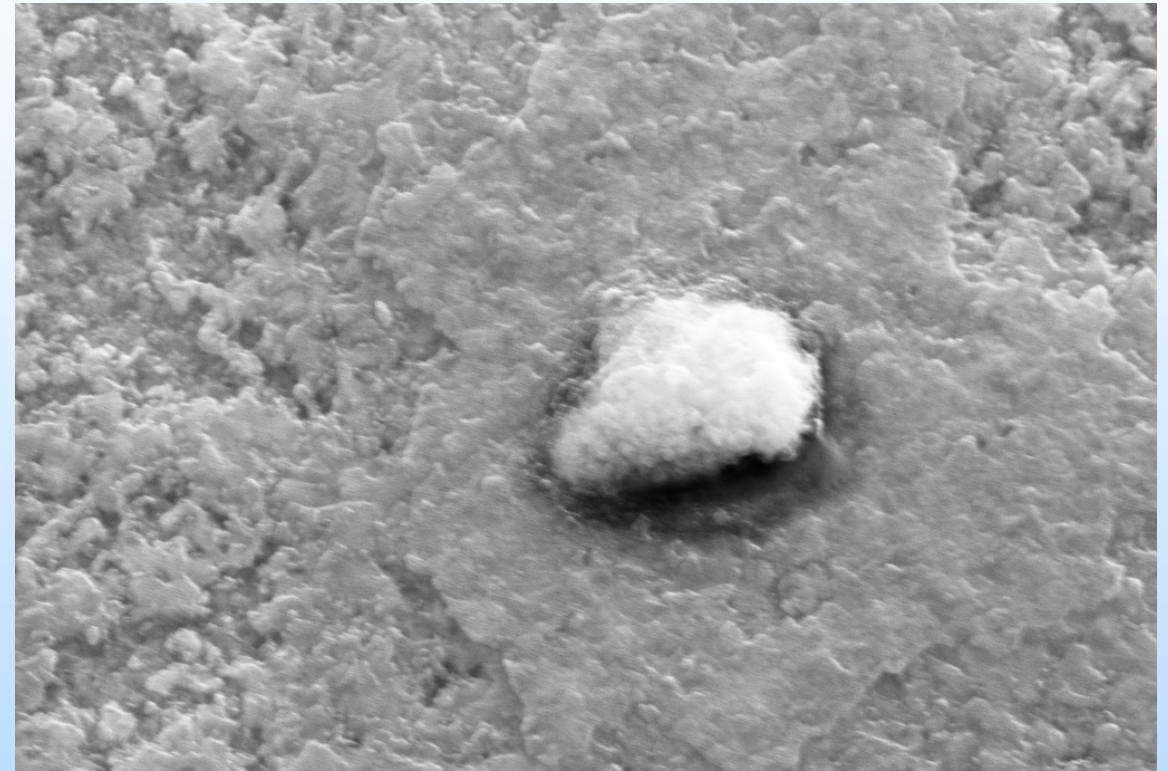
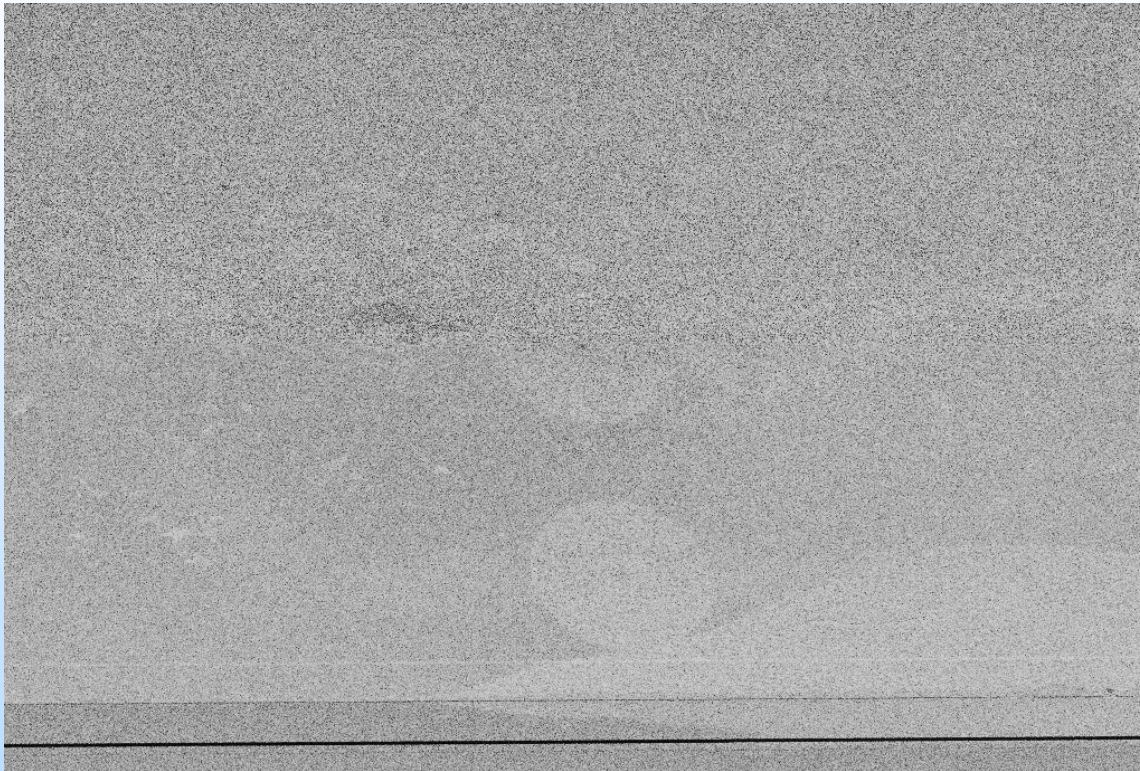
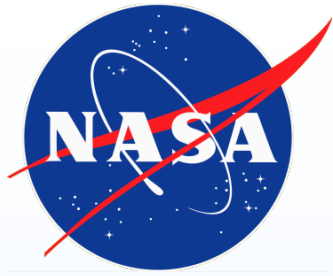


After chemical etches, a few small discolored locations were identified with displaced silicon at the center



# Degradation and Failure

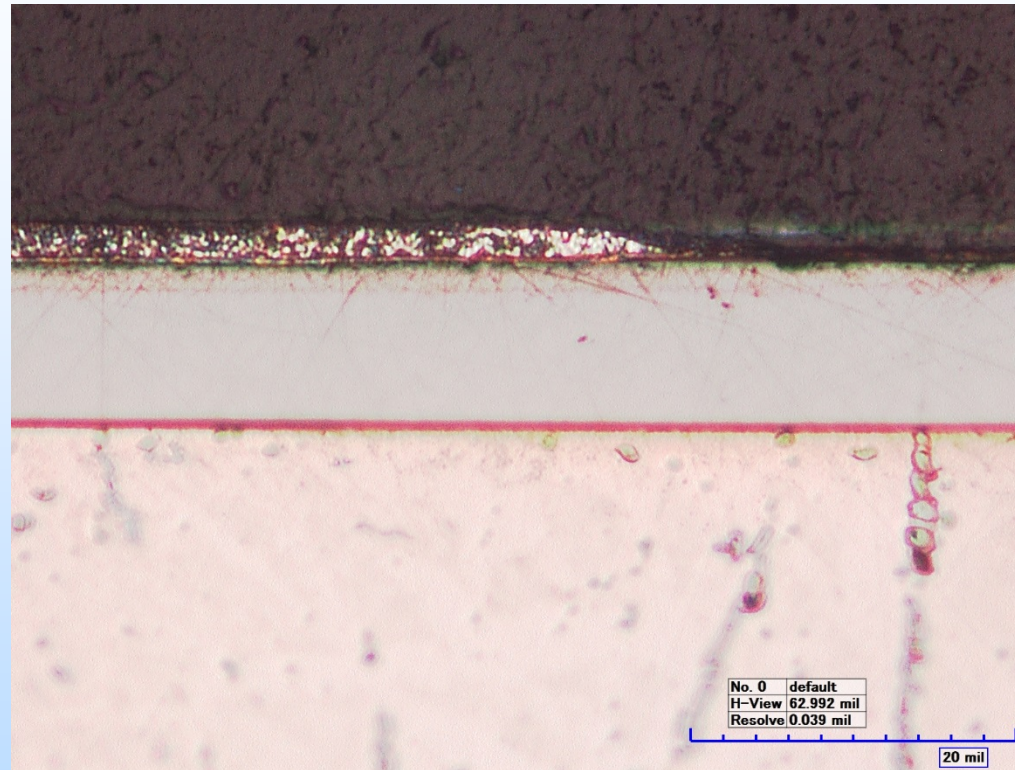
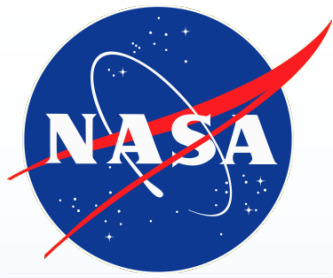
## Scanning Electron Microscope Images



Displaced silicon ball was unable to be removed from surface  
of the diode

# Degradation and Failure

## Cross-Section at Displaced Silicon Location

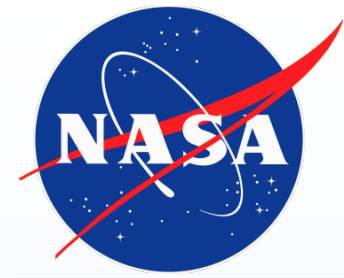


There is no damage structure visible in the damaged diode cross-section

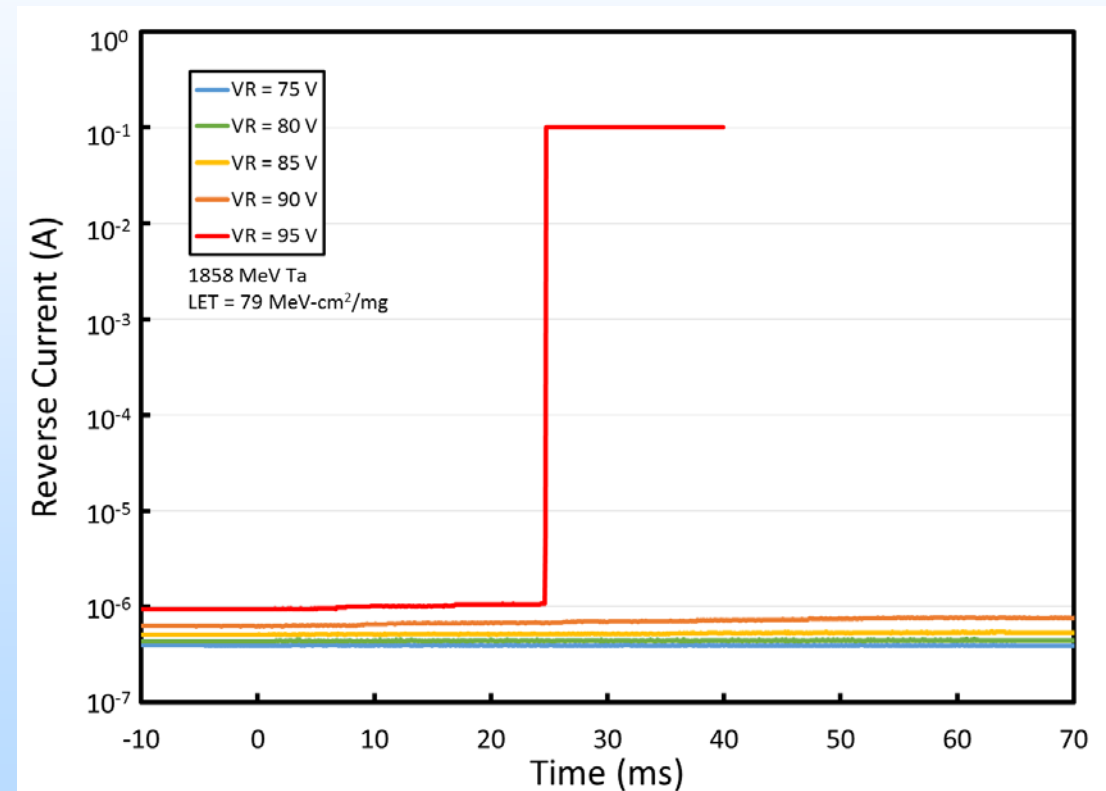


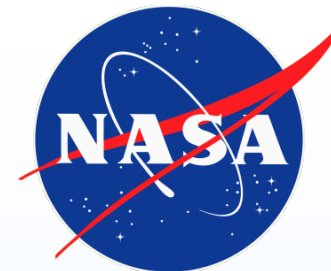
# Catastrophic Failure

## Power Supply Currents



- SN7 was irradiated with 1858 MeV Ta (LET = 79 MeV-cm<sup>2</sup>/mg) in 5 V steps starting at 75 V
- Only charge collection was observed up to the 85-V irradiation
- When biased at 90 V, a ~140 nA increase in  $I_R$  was observed
  - All post-irradiation parameter measurements remained within specification
- At 95 V, the current reached the maximum 100 mA allowed by the power supply, and the anode and cathode were shorted together

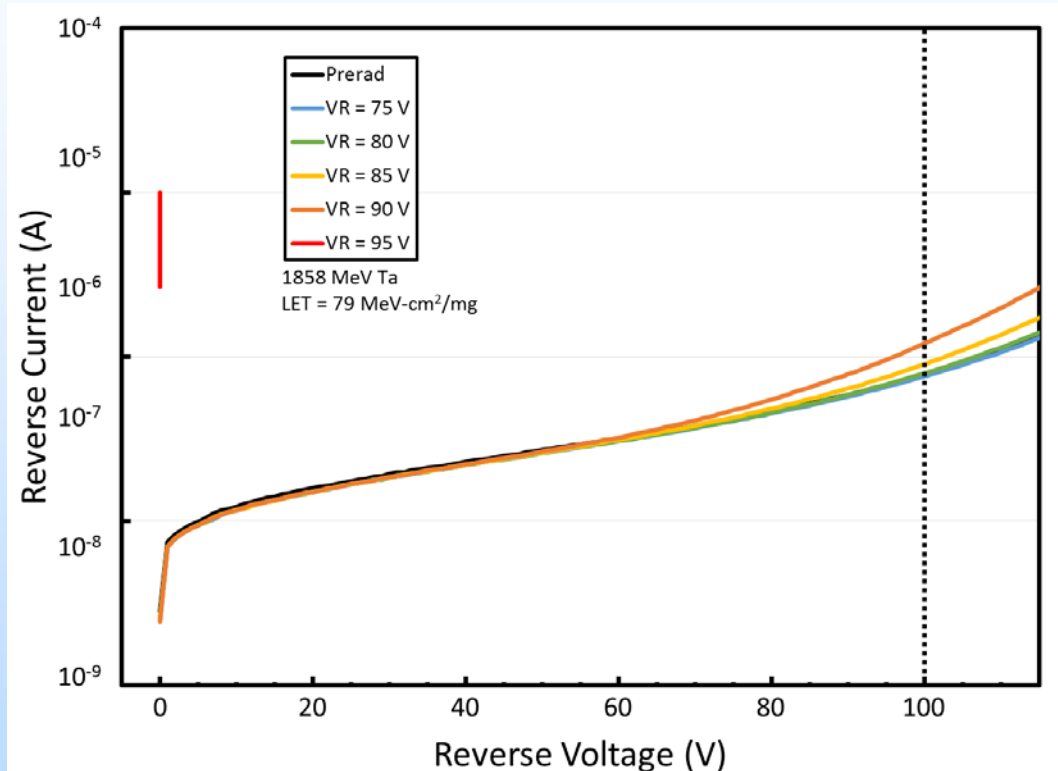




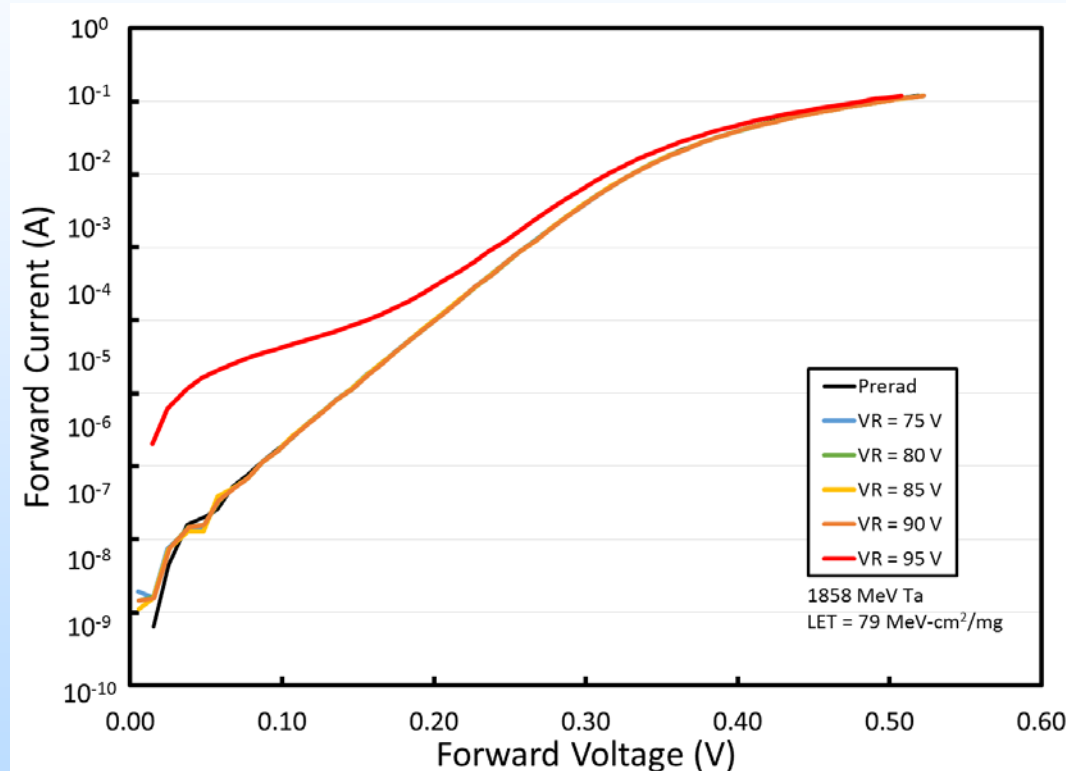
# Catastrophic Failure

## Post-Irradiation Electrical Measurements

### Reverse Current vs. Reverse Voltage



### Forward Current vs. Forward Voltage



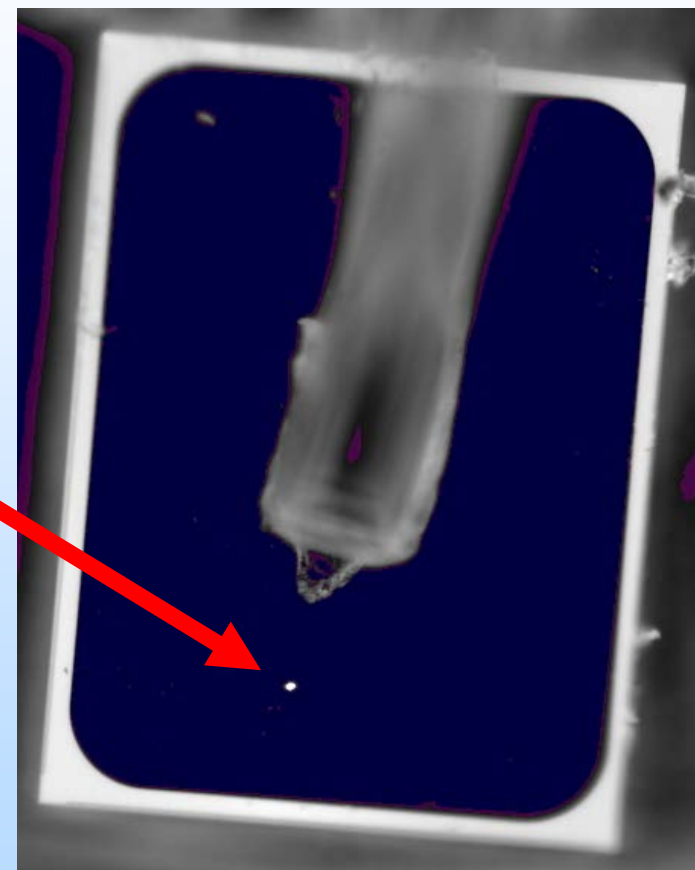
Almost no change was observed in the  $I_R$ - $V_R$  or  $I_F$ - $V_F$  plots until the 95-V irradiation, and then  $I_R$  exceeded 10  $\mu$ A at less than 1 V



# Catastrophic Failure

## Infrared Imaging of DUT

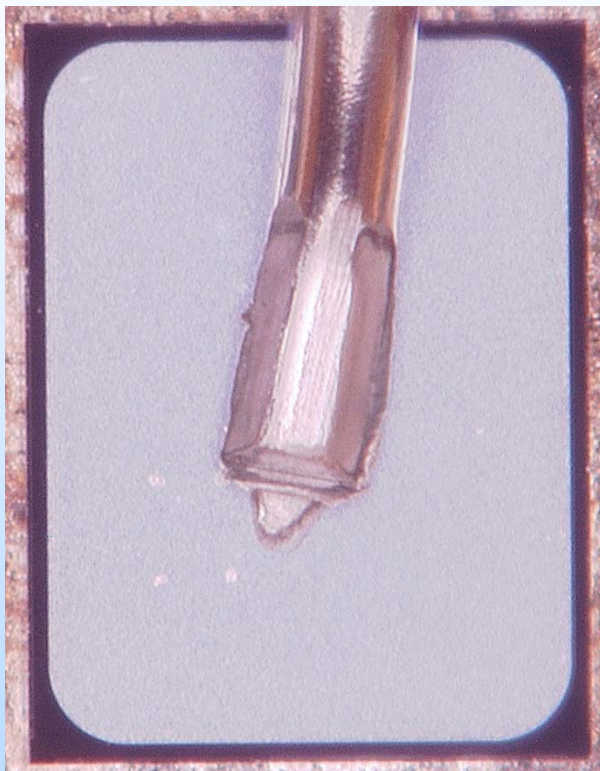
- Diode was examined using an IR camera and pictures were taken with a small voltage applied
  - Bright white spot just below the wirebond contact is the location of the failure
- Low-magnitude and high-magnitude optical images of the surface of the DUT did not show anything unusual at the location identified in the IR image



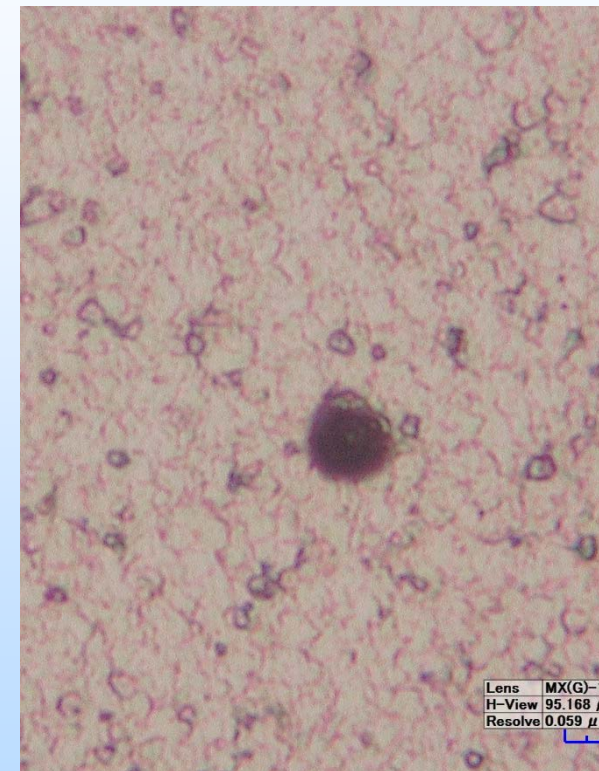
# Catastrophic Failure

Optical Images of DUT

Low-Magnification



High-Magnification



Unlike other part that experienced catastrophic failure, location is visible in high-magnification optical images

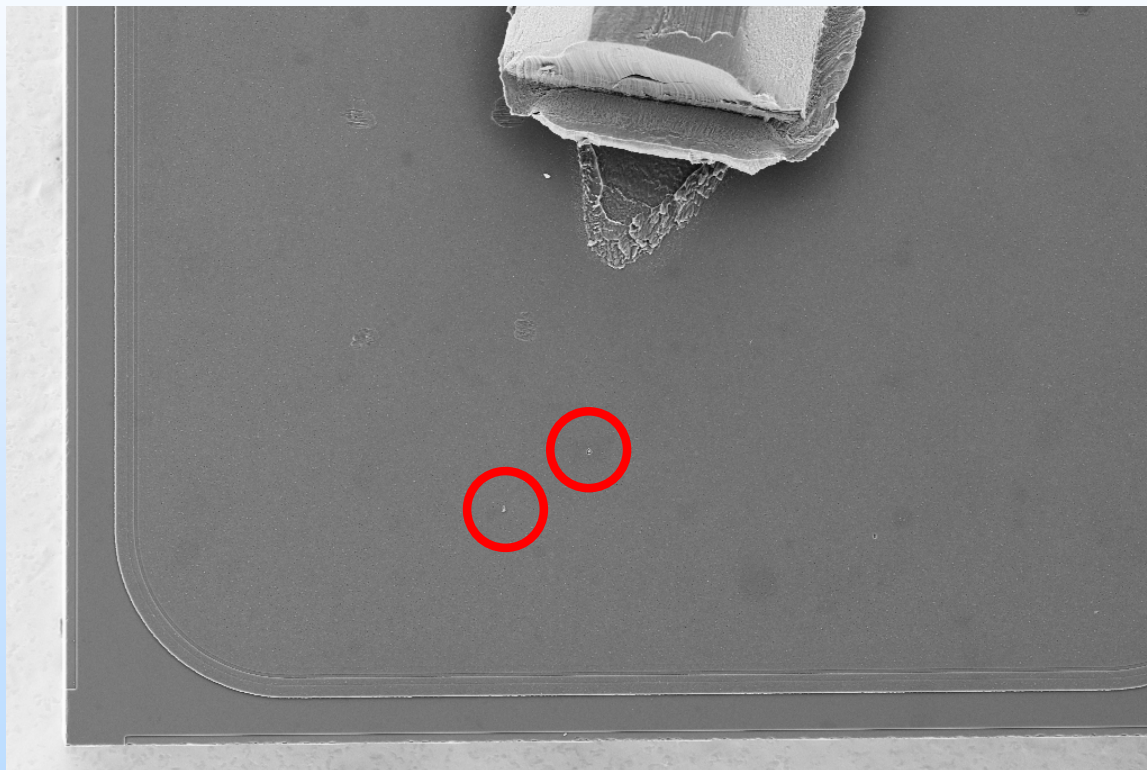




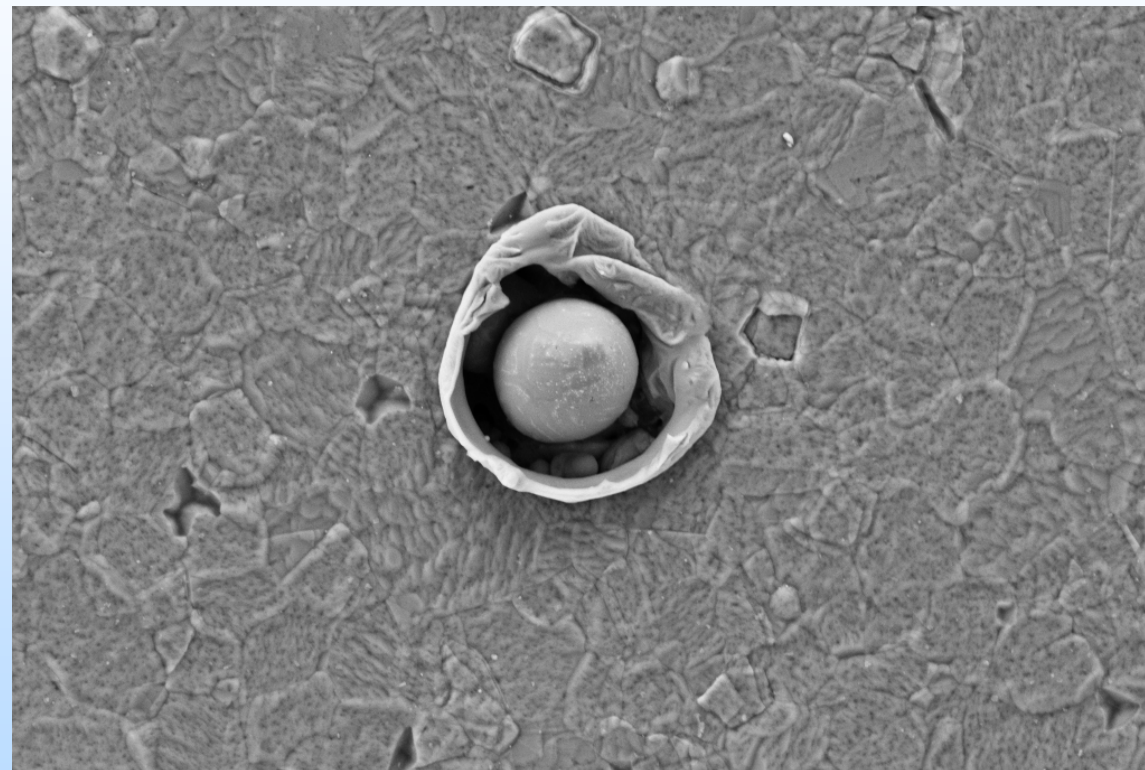
# Catastrophic Failure

Surface SEMs of Failure Location

**Low-Magnification SEM Image**



**Scanning Electron Microscope Image**





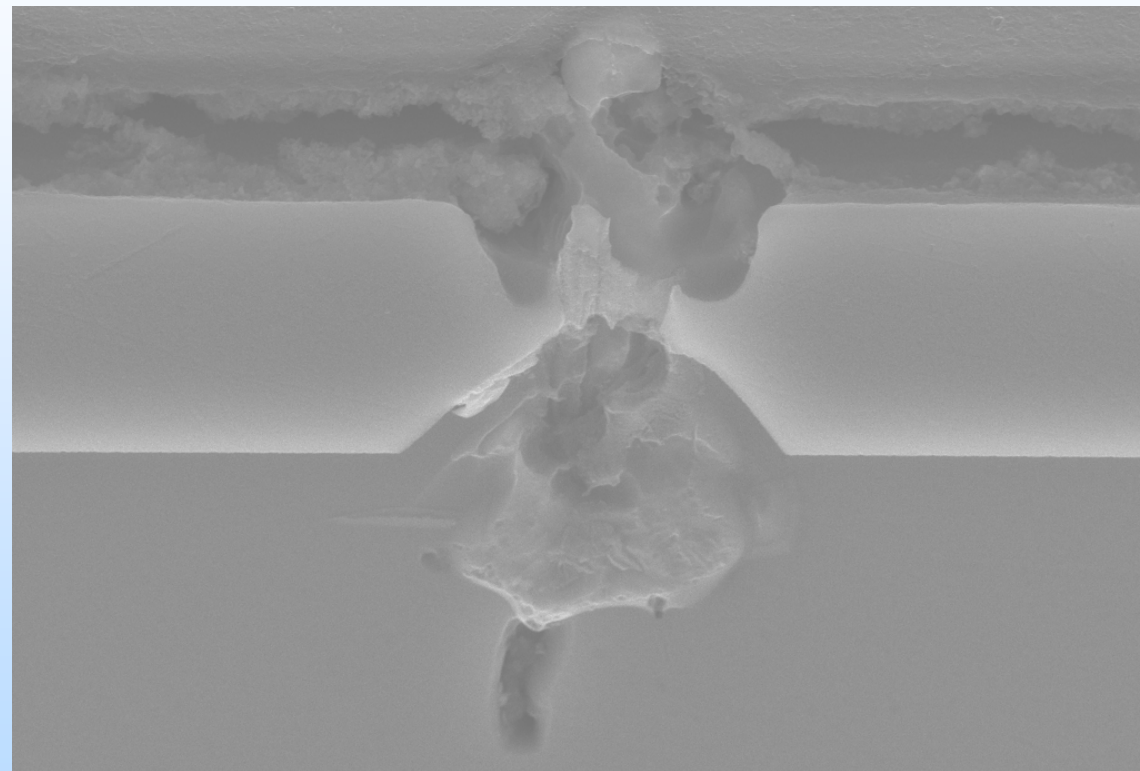
# Catastrophic Failure

Cross-Section at Failure Location

**High-Magnification Optical Image**



**Scanning Electron Microscope Image**



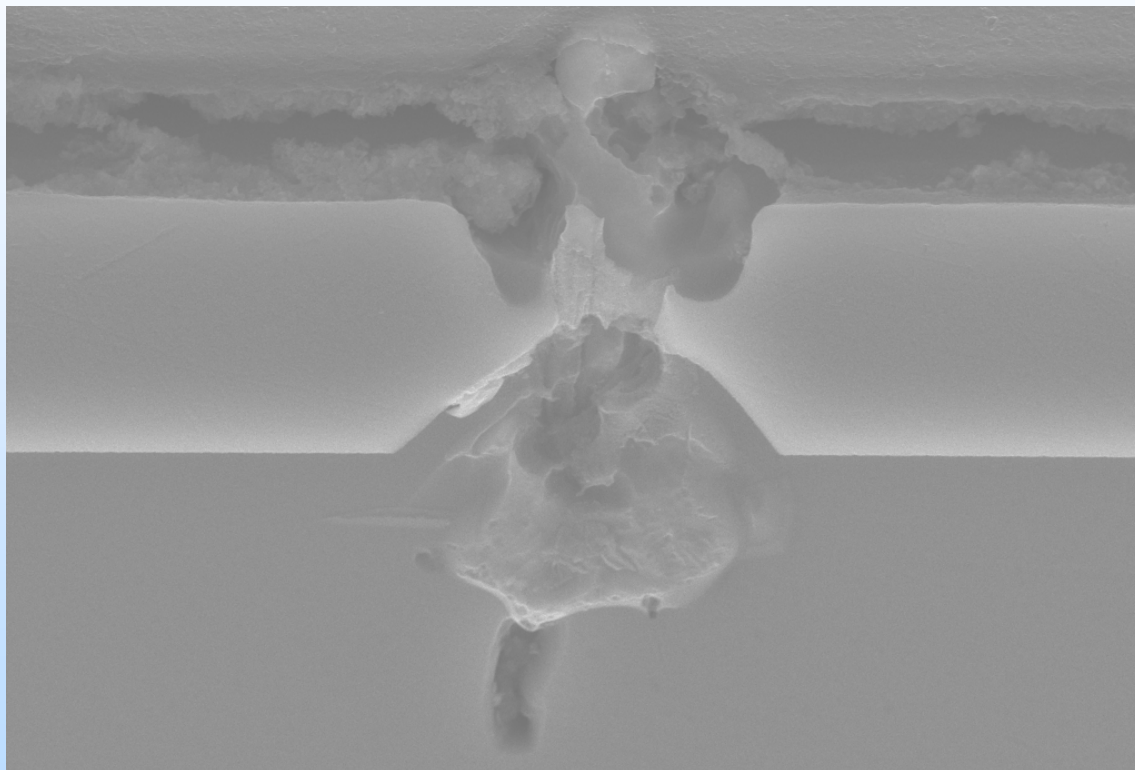




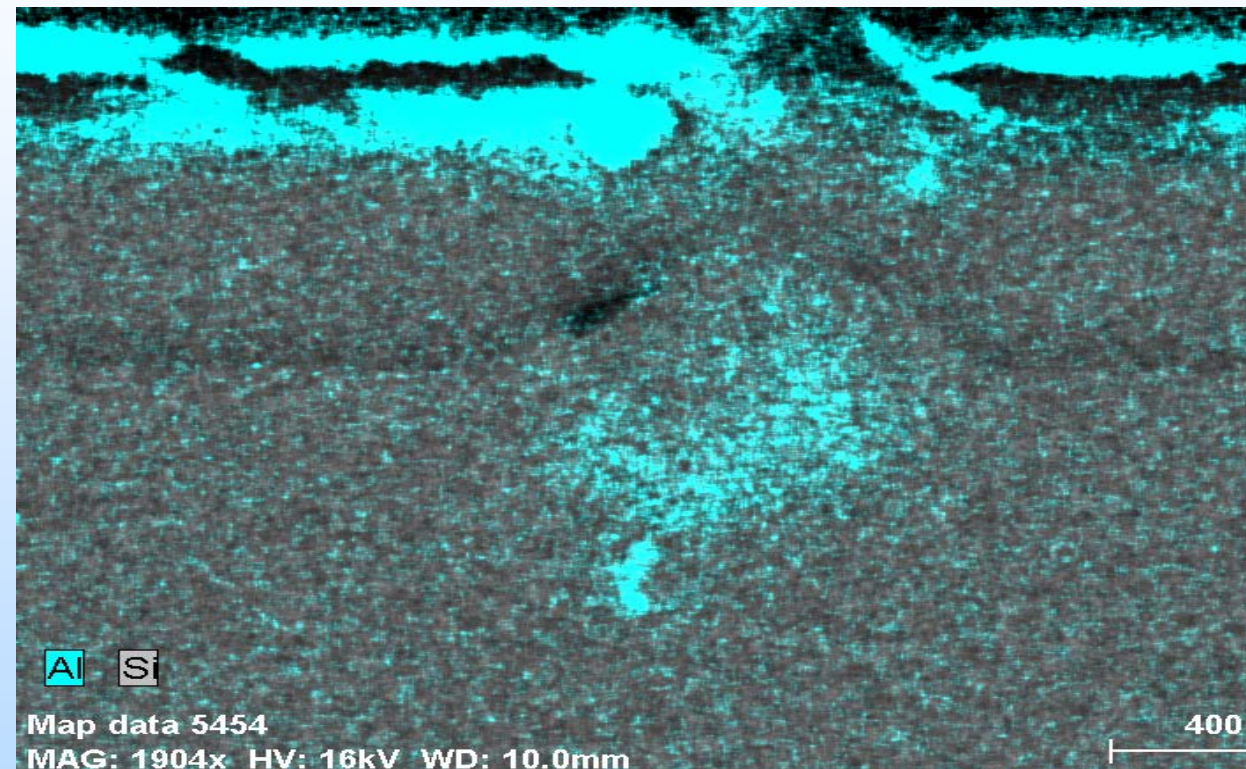
# Catastrophic Failure

Energy Dispersive X-Ray Spectroscopy

SEM Cross-Section Image



Map of Al and Si



Metal has clearly displaced from Schottky junction into void  
formed from high current



# Conclusions



# Conclusions

- Only diodes with a Schottky junction appear to experience catastrophic failure under the conditions tested
  - Degradation was observed in an RF switching diode and several Zener diodes
    - While all measured electrical parameters remained within specification after degradation was observed, the long-term reliability of these parts is unknown
  - Degradation and failure mechanisms are not limited to power devices
- 
- Failure analysis shows clear failure locations in parts that experience catastrophic failure when examined with an IR camera
  - Parts that experience degradation do not appear to have deep internal failure structures that are observable when cross-sectioned
  - When the anode and cathode short in diodes due to destructive SEEs, Schottky metal displaces and creates the conducting path



# Backup Slides

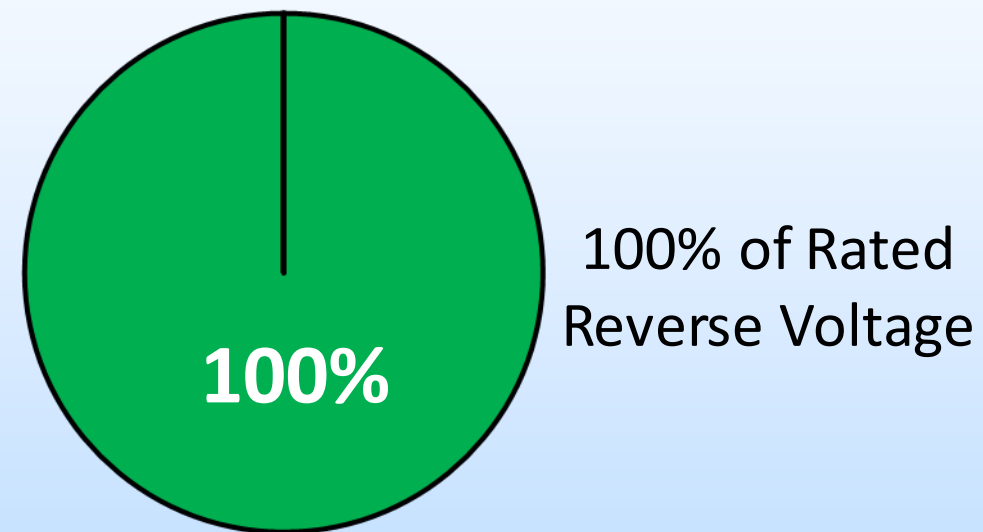




# Results – Avalanche Diode

- Only one avalanche diode type was tested
  - We were limited in our options due to packaging issues

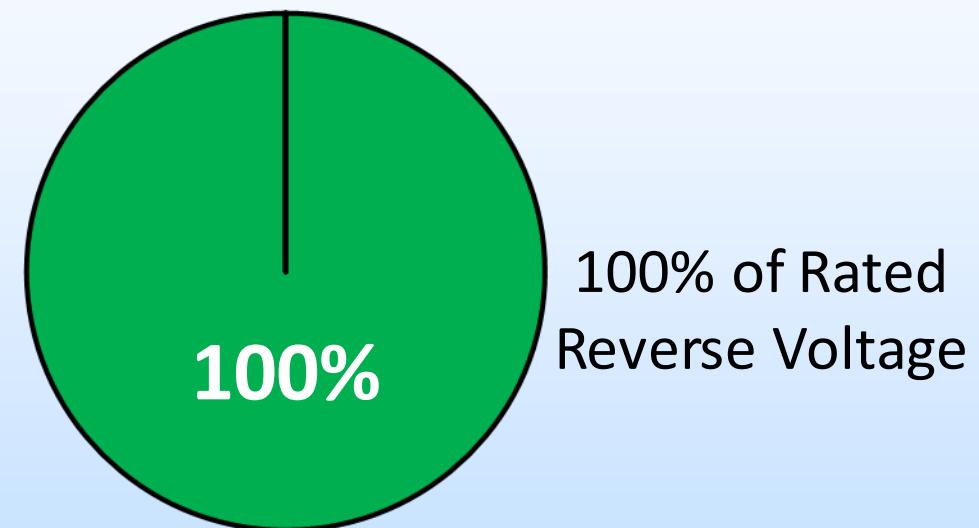
Manufacturer	Part Number	Reverse Voltage	Forward Current
NXP Semi	BAS29,215	90 V	200 mA





# Results – PiN Diodes

Manufacturer	Part Number	Reverse Voltage	Forward Current
NXP Semi	BAT18,215	35 V	100 mA
NXP Semi	BAP50-05,215	50 V	50 mA
Broadcom	HSMP-3810-TR1G	100 V	1 A
M/A-COM	MA4P7455CK-287T	100 V	150 mA
Infineon	BAR64-05 E6327	150 V	100 mA
NXP Semi	BAP64-05,215	175 V	100 mA
Skyworks	SMP1307-004LF	200 V	100 mA





# Diodes, Inc. BAS21-7-F Switching Diode

- Small changes in the reverse current were observed during the runs in which these parts were biased at the full-rated 200-V reverse voltage
- Small changes in the  $I_R$ - $V_R$  and  $I_F$ - $V_F$  plots were observed after the runs
  - How these changes effect the long-term reliability of the parts is unknown

